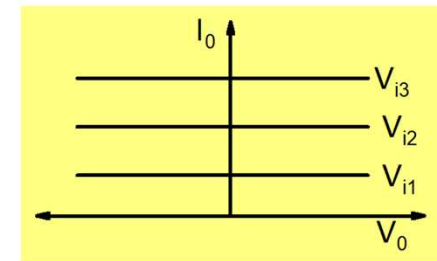
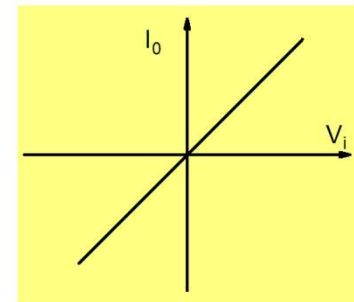
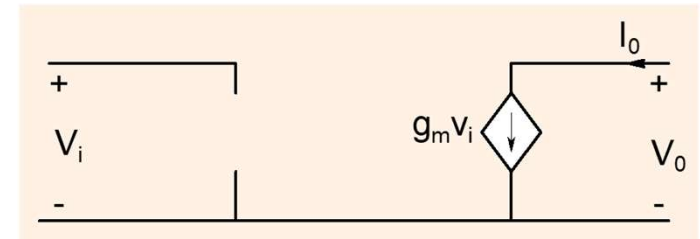


# ESC201T: Introduction to Electronics

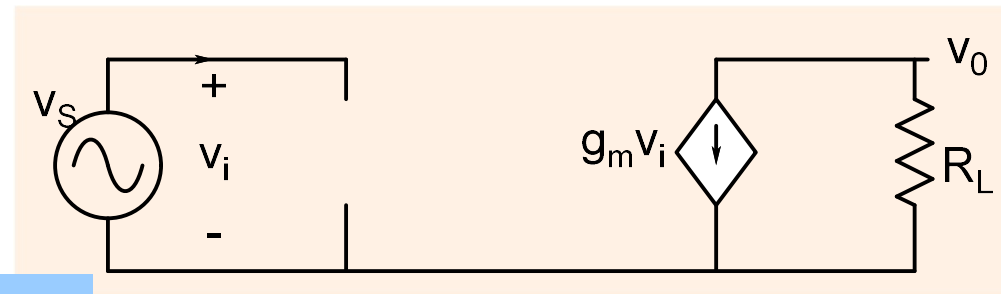
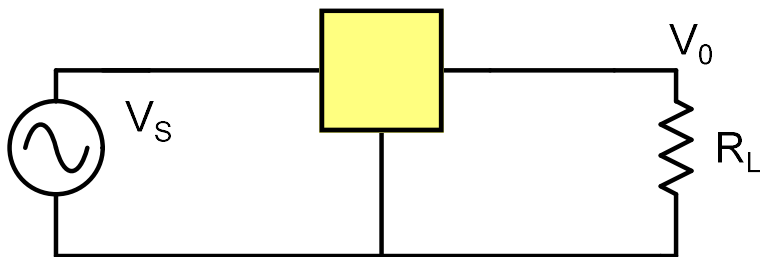
## Lecture 27: Transistors

B. Mazhari  
Dept. of EE, IIT Kanpur

# Transistor

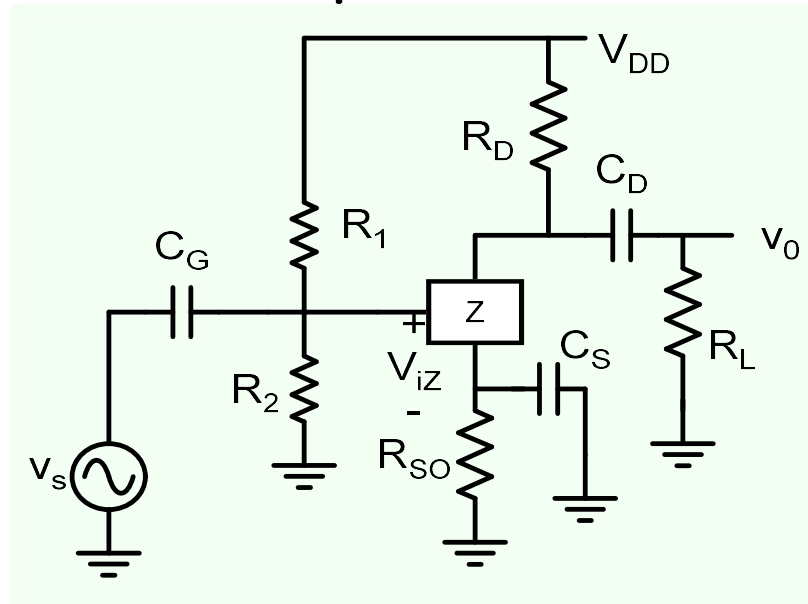
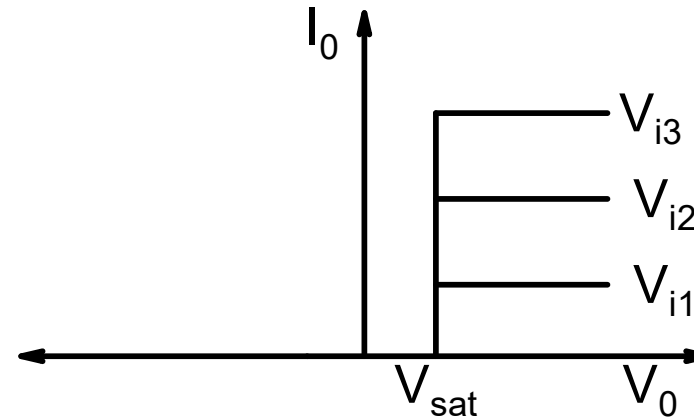
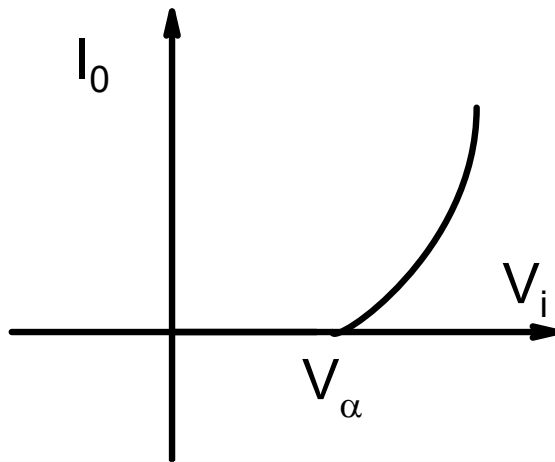


Current  $I_O$  is much more sensitive to  $V_{IN}$  than  $V_O$



$$A_V = \frac{V_o}{V_s} = -g_m \times R_L$$

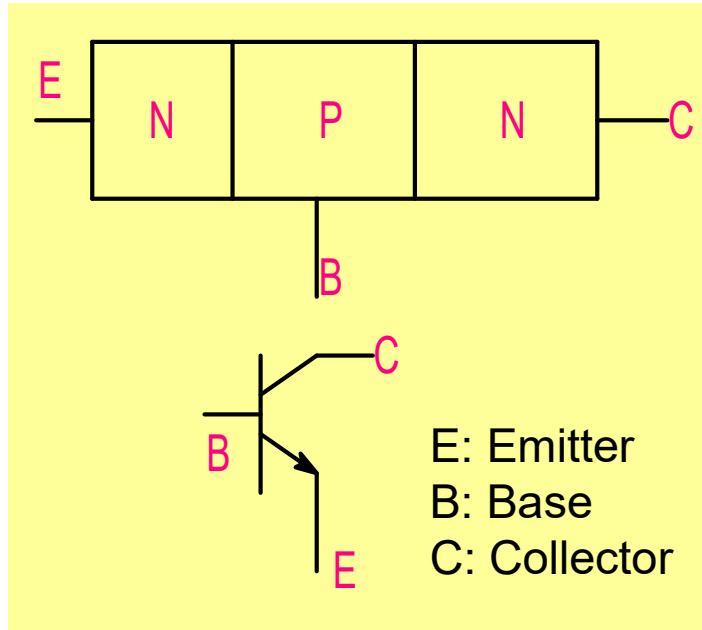
## Building Amplifiers with non-linear devices



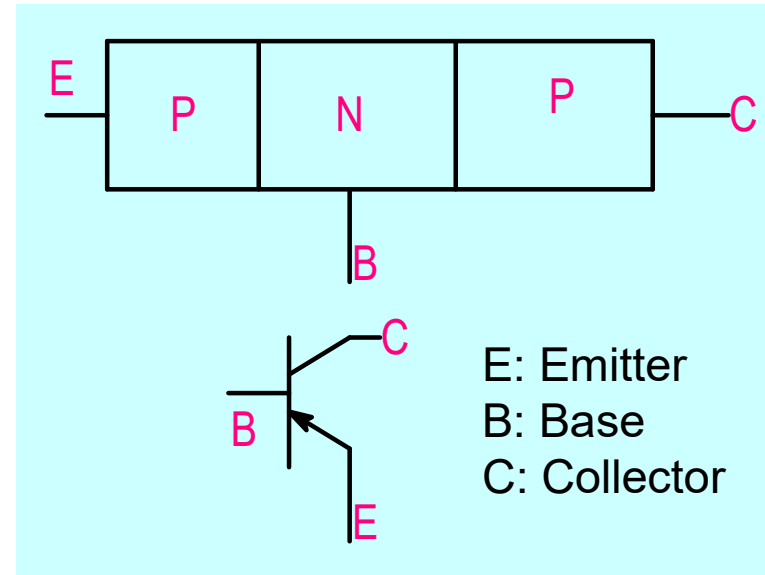
Amplifier will work properly (with small distortion only if we restrict the amplitude of input signal to small values.

How small depends on the nature of non-linearity. The stronger the non-linearity the lesser the signal amplitude.

## Bipolar Junction Transistor (BJT)

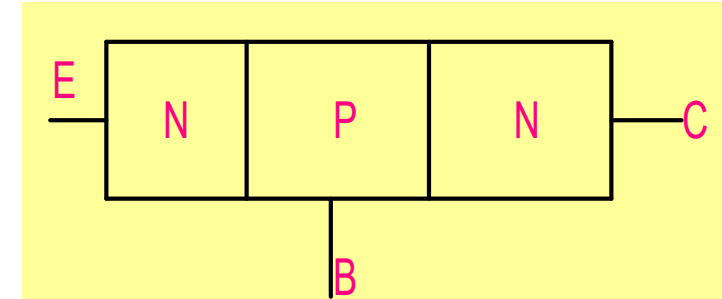
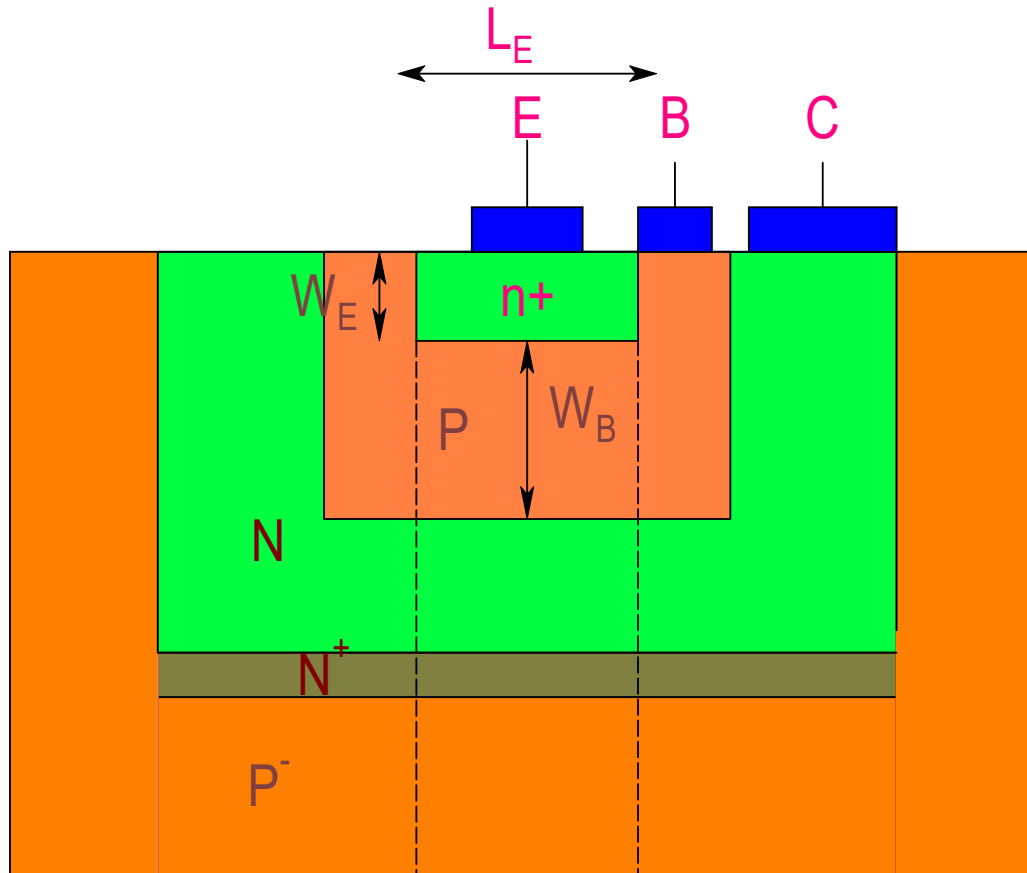


  
NPN



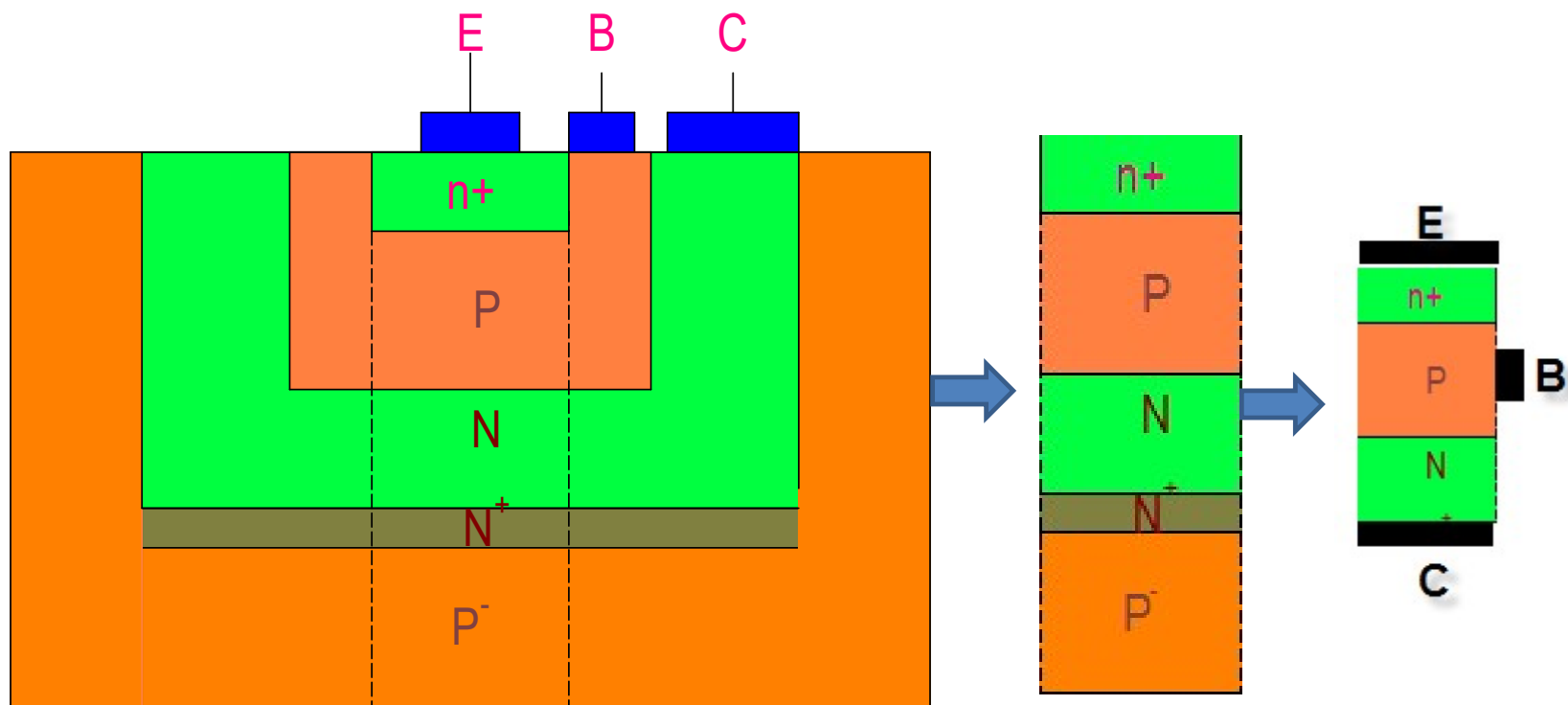
PNP

## More Realistic View

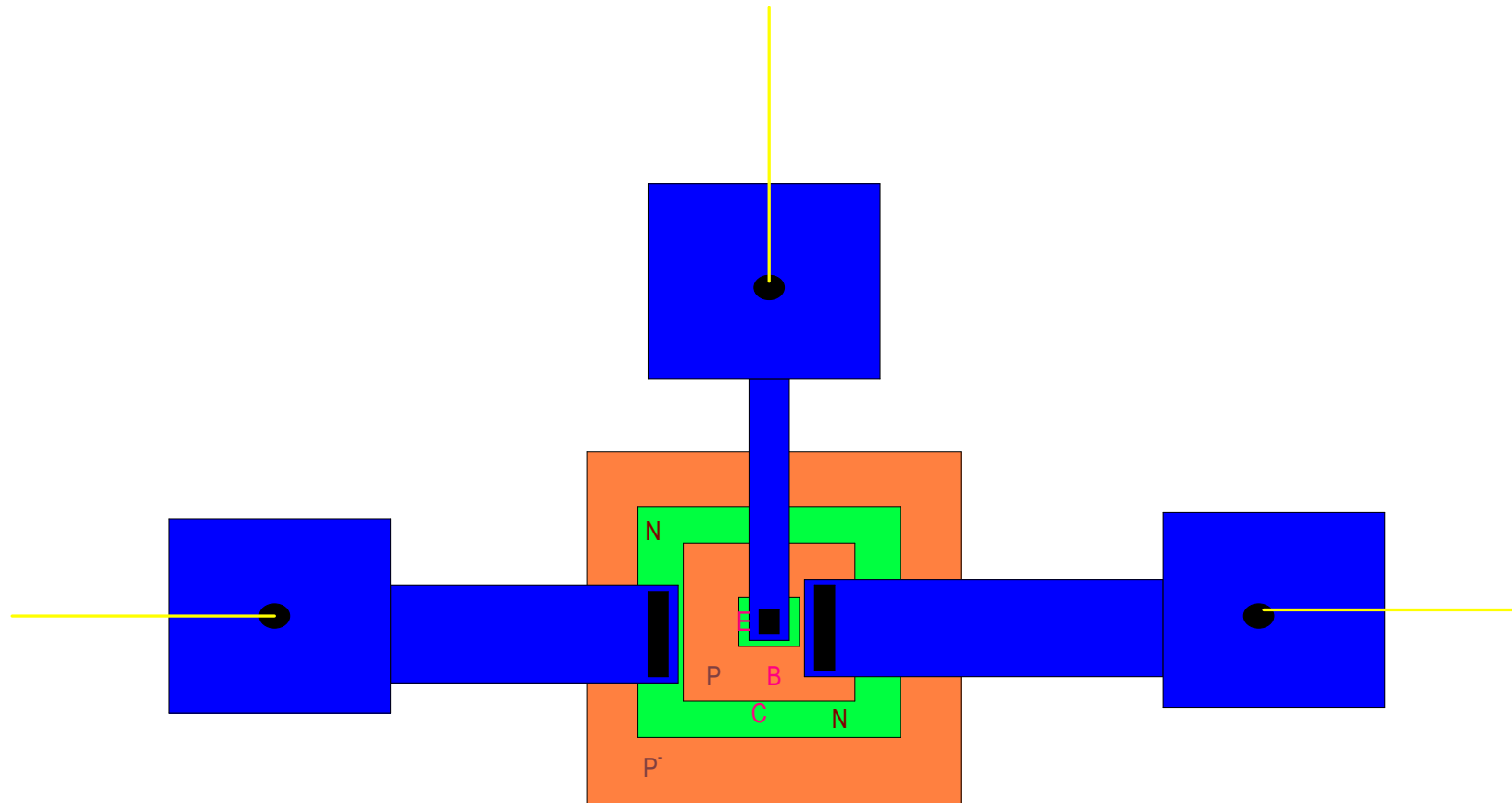


$$\begin{aligned} N_{DE} &\sim 10^{19} \text{ cm}^{-3} \\ N_{AB} &\sim 10^{17} \text{ cm}^{-3} \\ N_{DC} &\sim 10^{16} \text{ cm}^{-3} \\ W_B &\sim 2000 \text{ \AA} \\ W_E &\sim 1000 \text{ \AA} \\ L_E &\sim 1 \mu\text{m} \end{aligned}$$

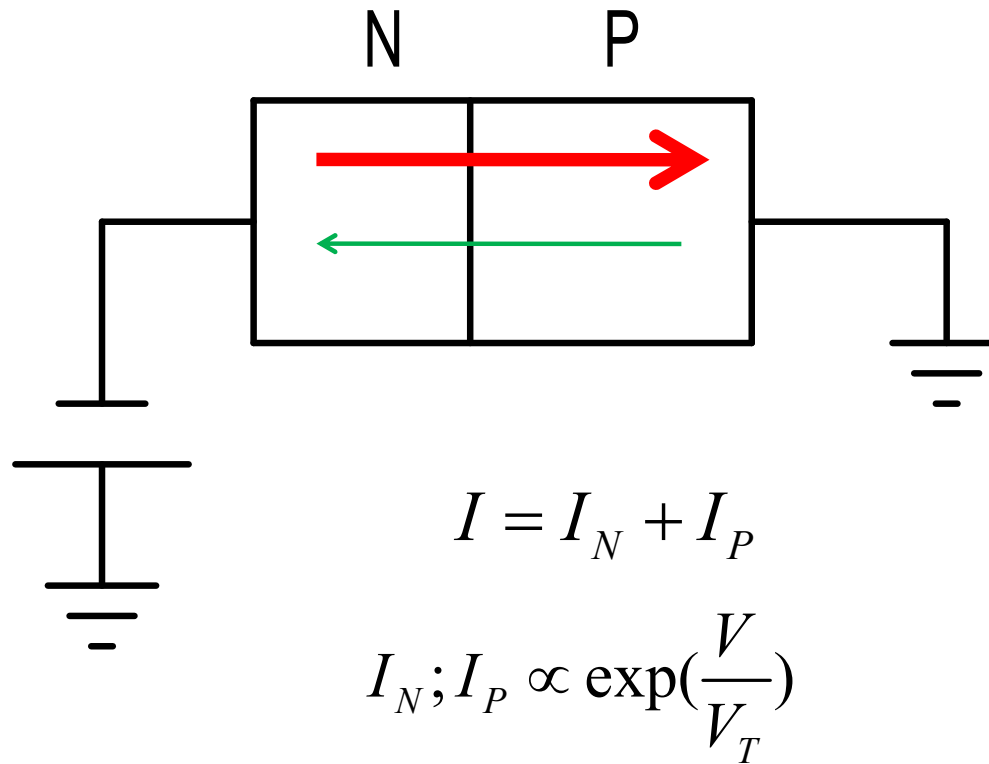
BJT is not symmetric: emitter and collector cannot be simply interchanged



Top View



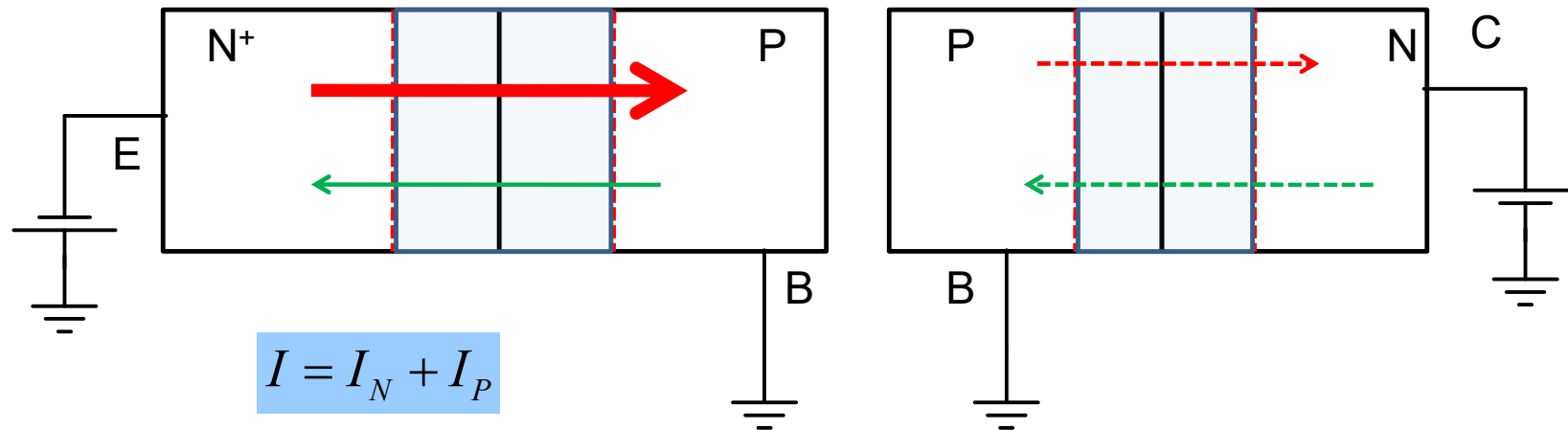
## Background



If doping in N region is much larger than doping in p region  
then  $I_N \gg I_P$



## Basic Transistor Operation



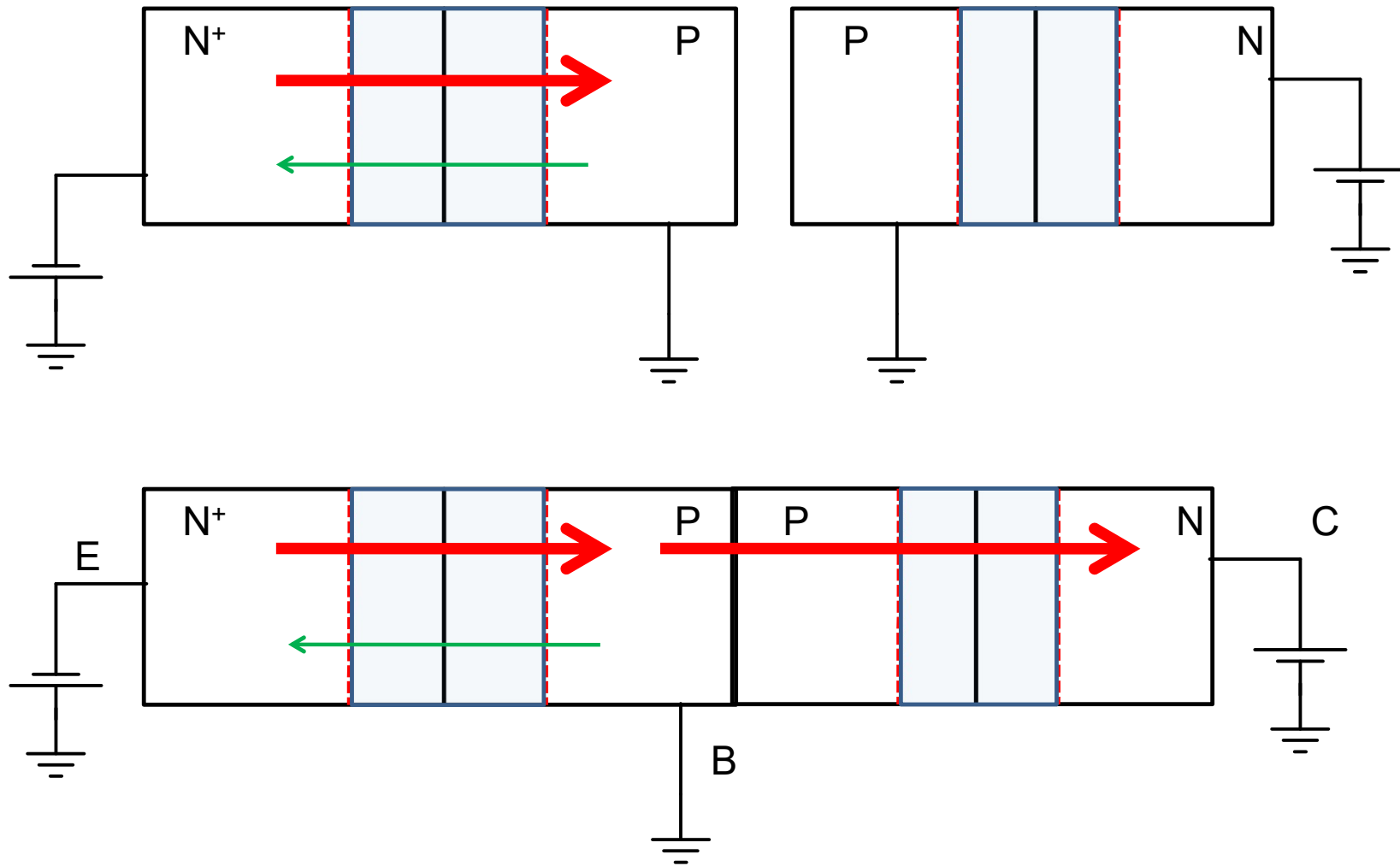
We will assume that doping in emitter is much more than base so that electron current is much larger than hole current

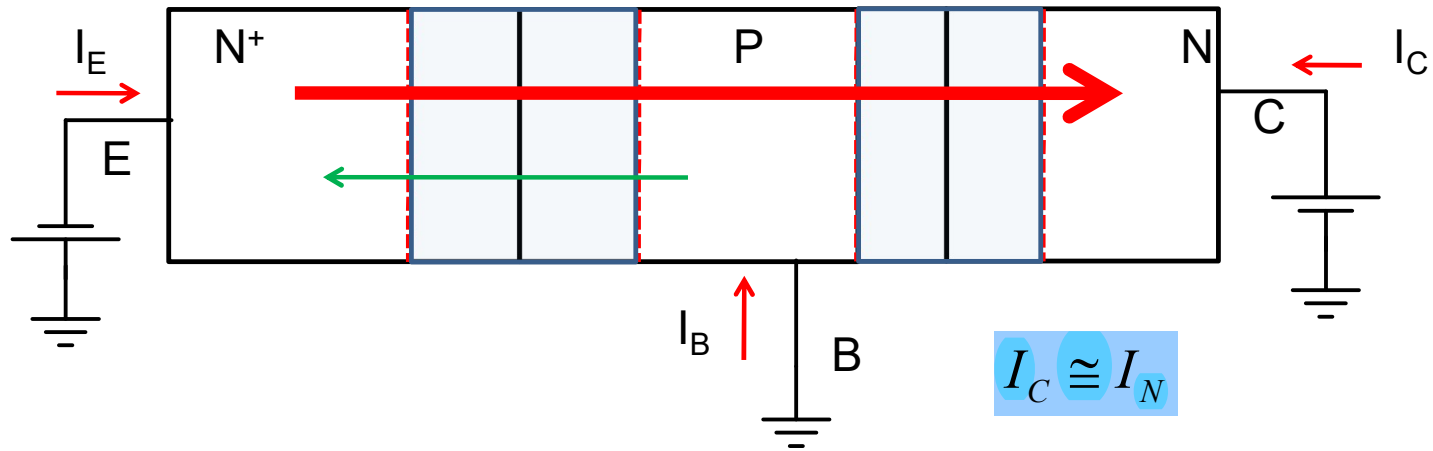
$$I_N \gg I_P$$

In the reverse biased junction current is small because there are very few electrons in  $P$  and holes in  $N$ -region

## Basic Transistor Operation

$$I = I_N + I_P$$

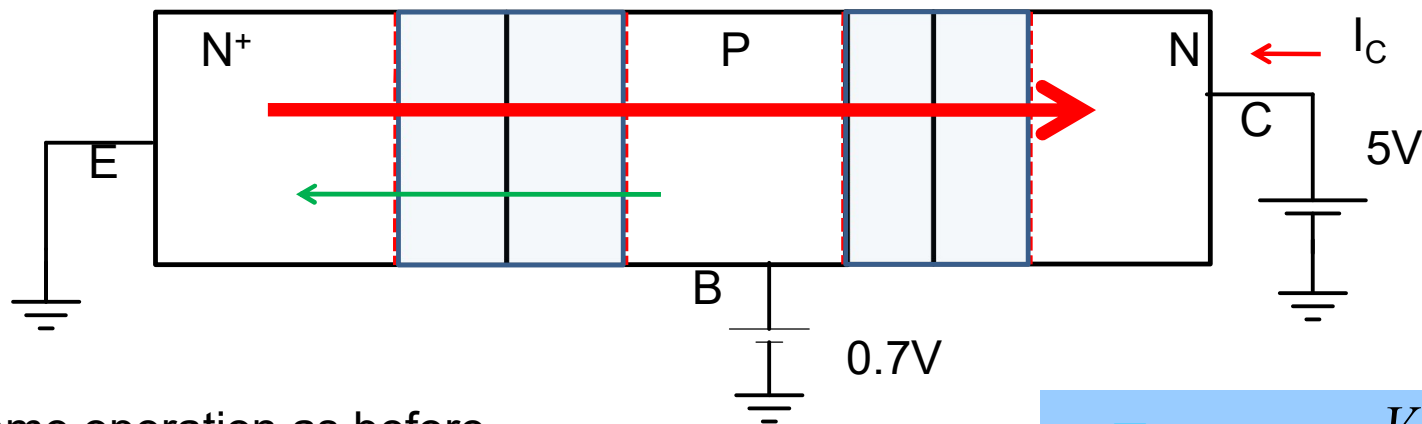




$$I_E = I_N + I_P$$

$$I_B \approx I_P$$

Current Gain :  $\beta = \frac{I_C}{I_B} = \frac{I_N}{I_P} \gg 1$

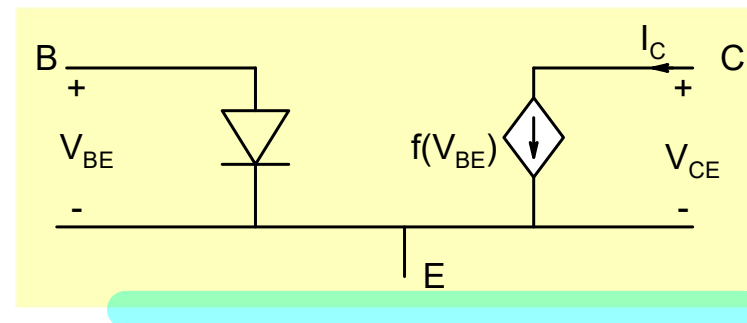
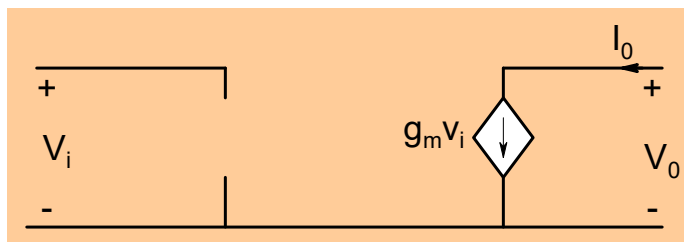


Same operation as before

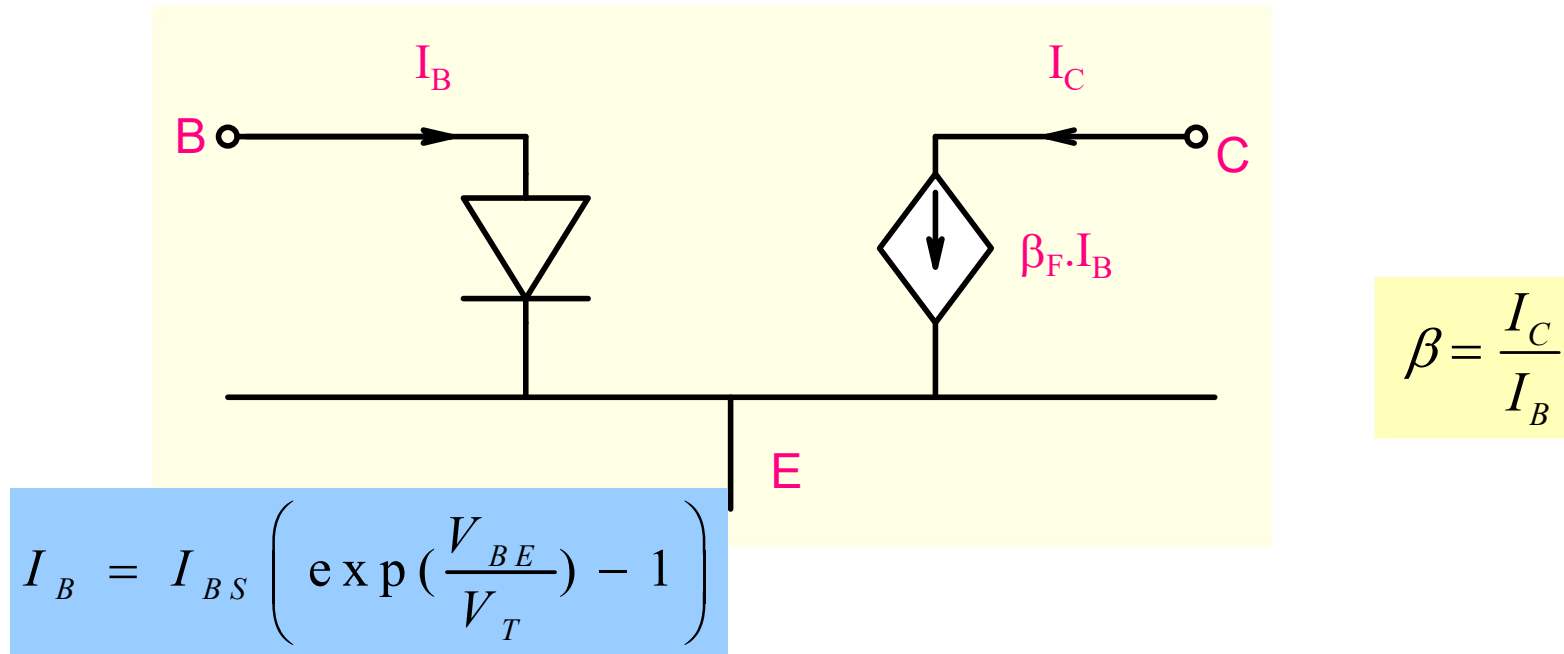
$$I_C = I_N \propto \exp\left(\frac{V_{BE}}{V_T}\right)$$

## Transistor action

Current is affected by base-emitter voltage and not by collector-base voltage

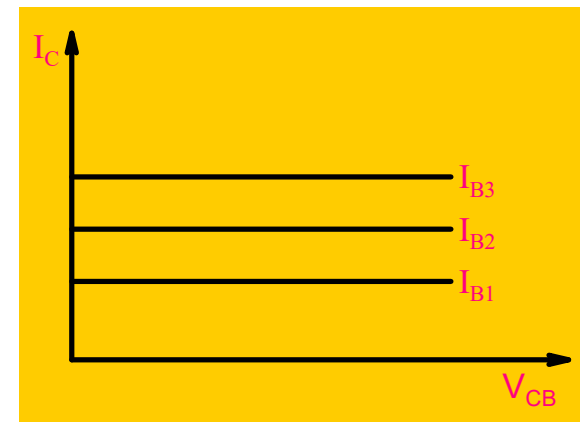
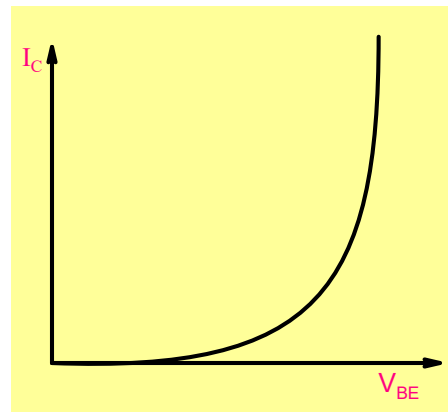
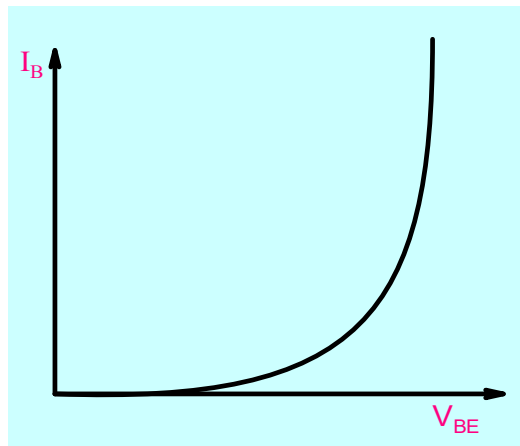
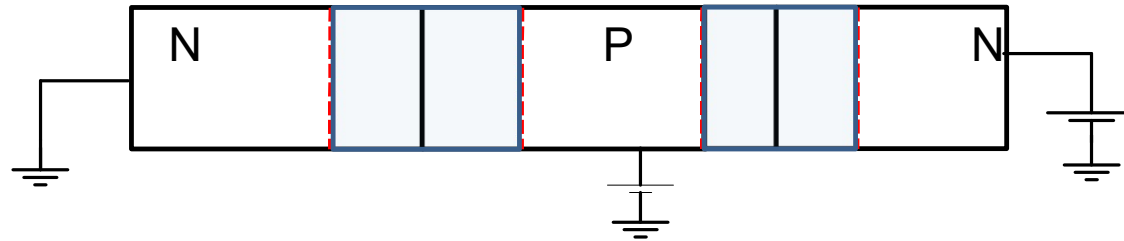


## Alternative representation

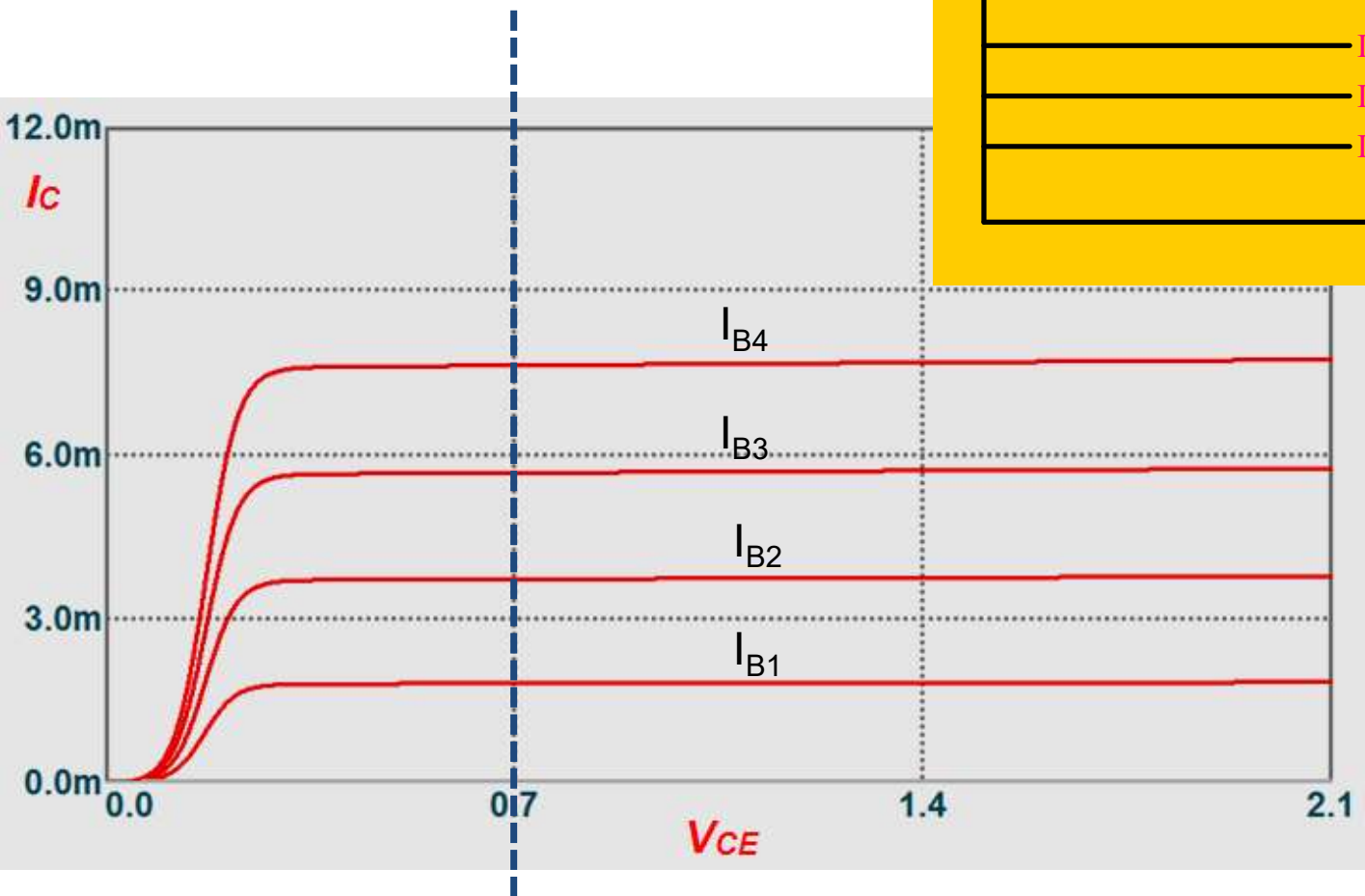


$$I_C = I_S \left( \exp\left(\frac{V_{BE}}{V_T}\right) - 1 \right)$$
$$I_B = \frac{I_C}{\beta_F}$$

# Transistor Characteristics



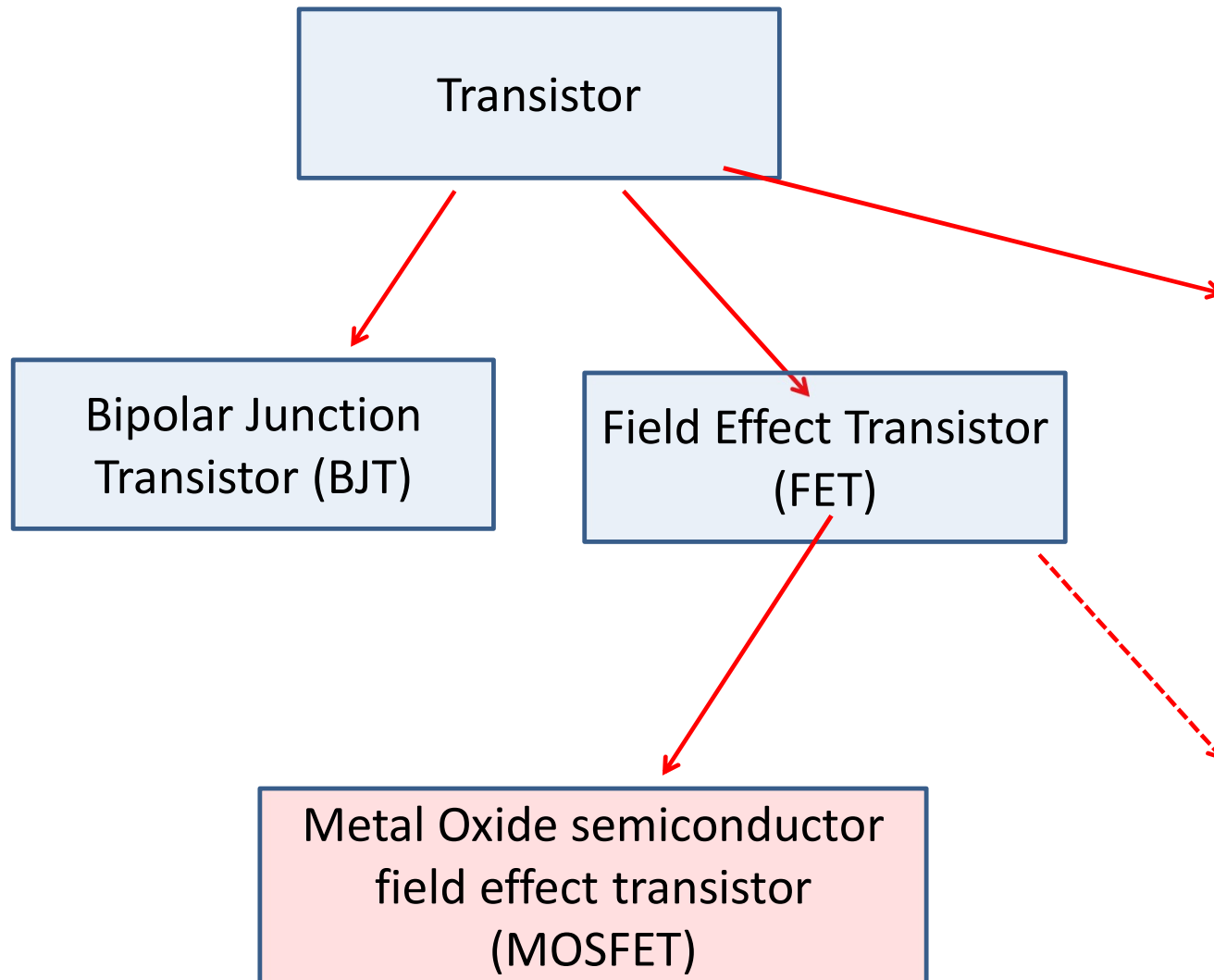
Output Characteristics of the transistor



$$V_{CE} = V_{CB} + V_{BE}$$
$$V_{BE} = V_{BE} - V_{BC}$$

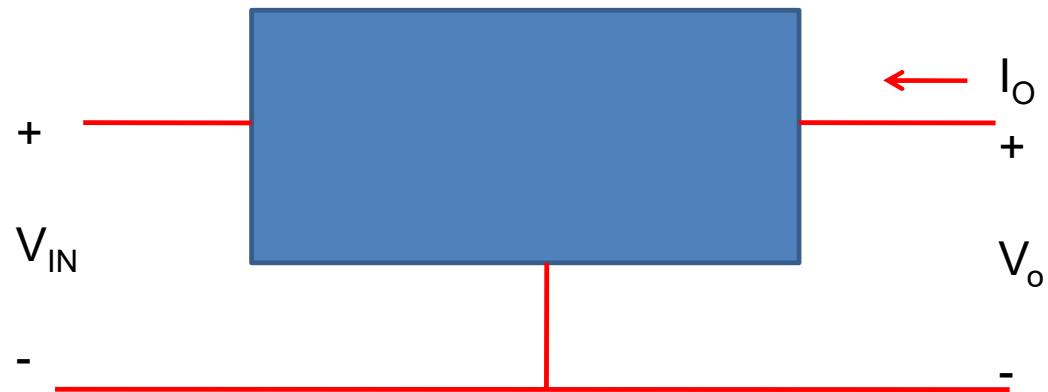
$$V_{CE} = 0.7 - V_{BC}$$

# Transistors





# Transistor

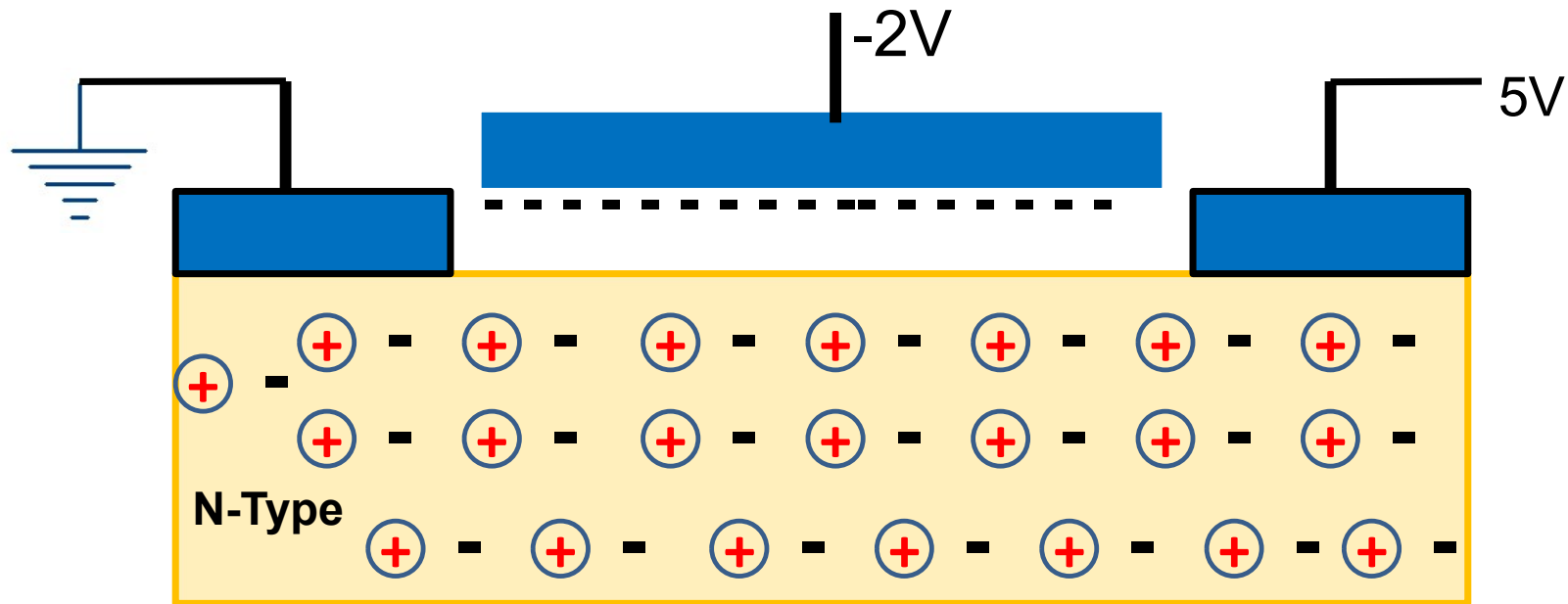


Current  $I_o$  is much more sensitive to  $V_{IN}$  than  $V_o$

$$\frac{\partial I_o}{\partial V_{in}} \gg \frac{\partial I_o}{\partial V_o}$$

## Field Effect Principle

$$\frac{\partial I_o}{\partial V_{in}} \gg \frac{\partial I_o}{\partial V_o}$$



Modulation of conductivity using electric field

Transconductance

Jan. 28, 1930.

J. E. LILIENFELD

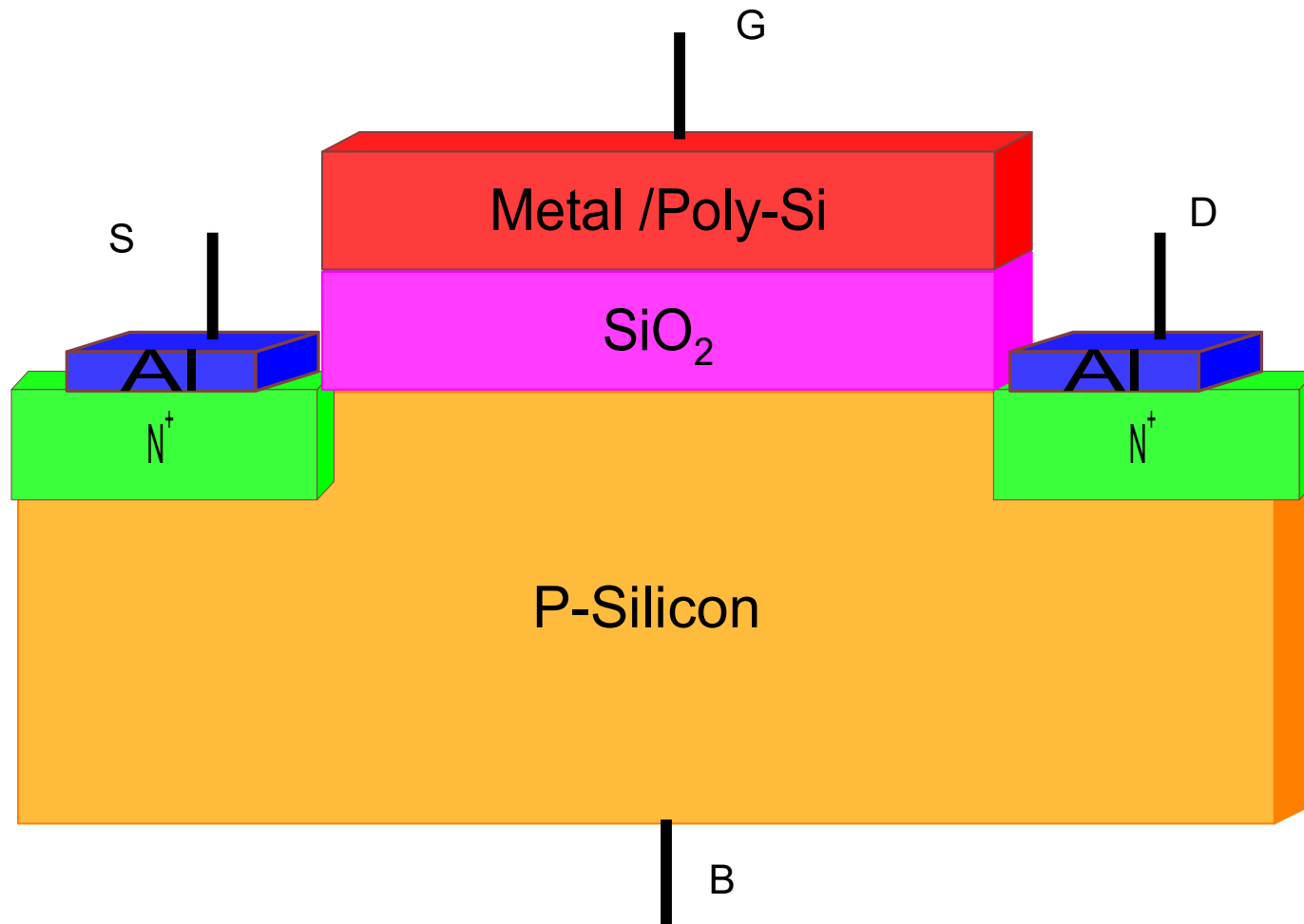
1,745,175

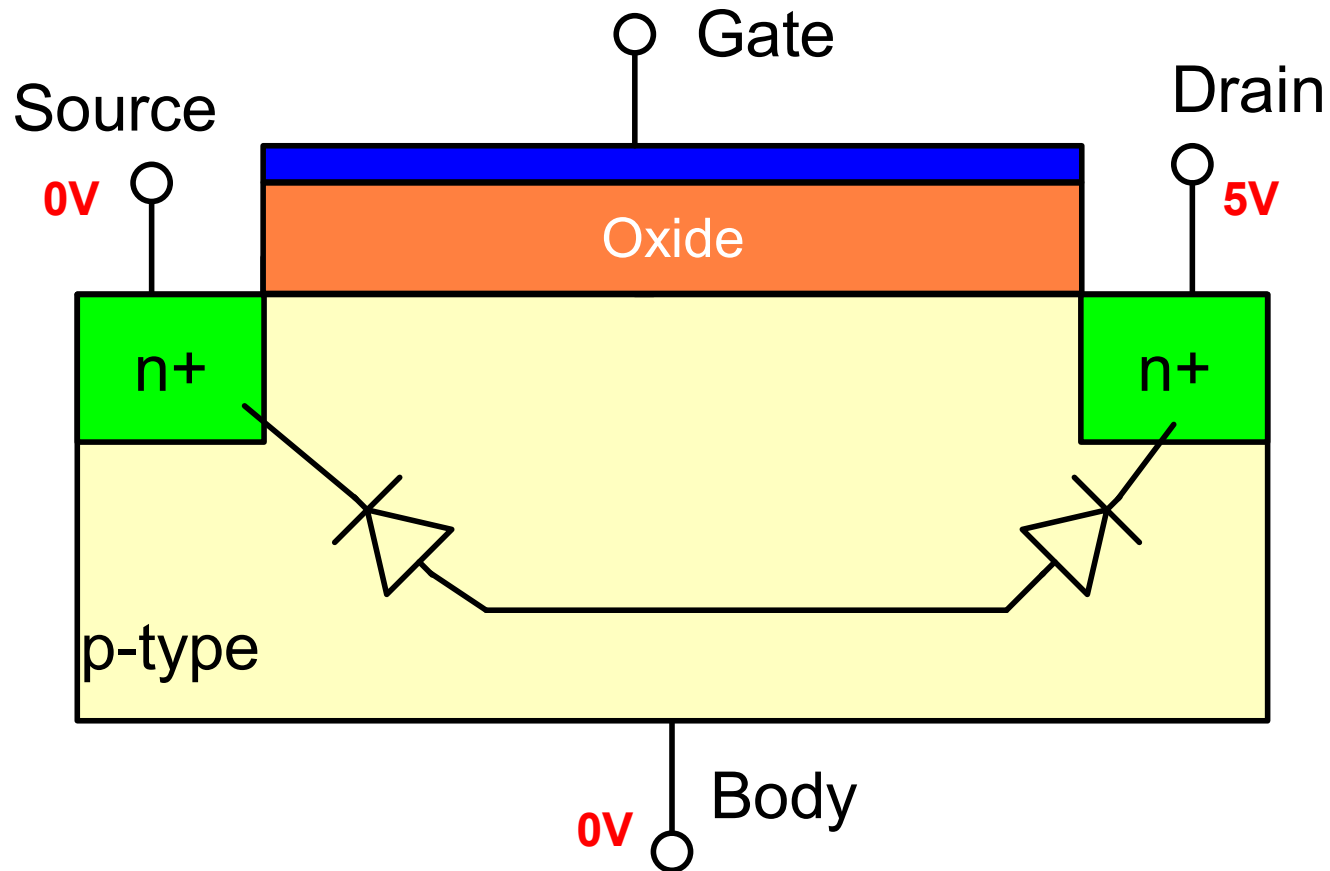
METHOD AND APPARATUS FOR CONTROLLING ELECTRIC CURRENTS

Filed Oct. 8, 1926

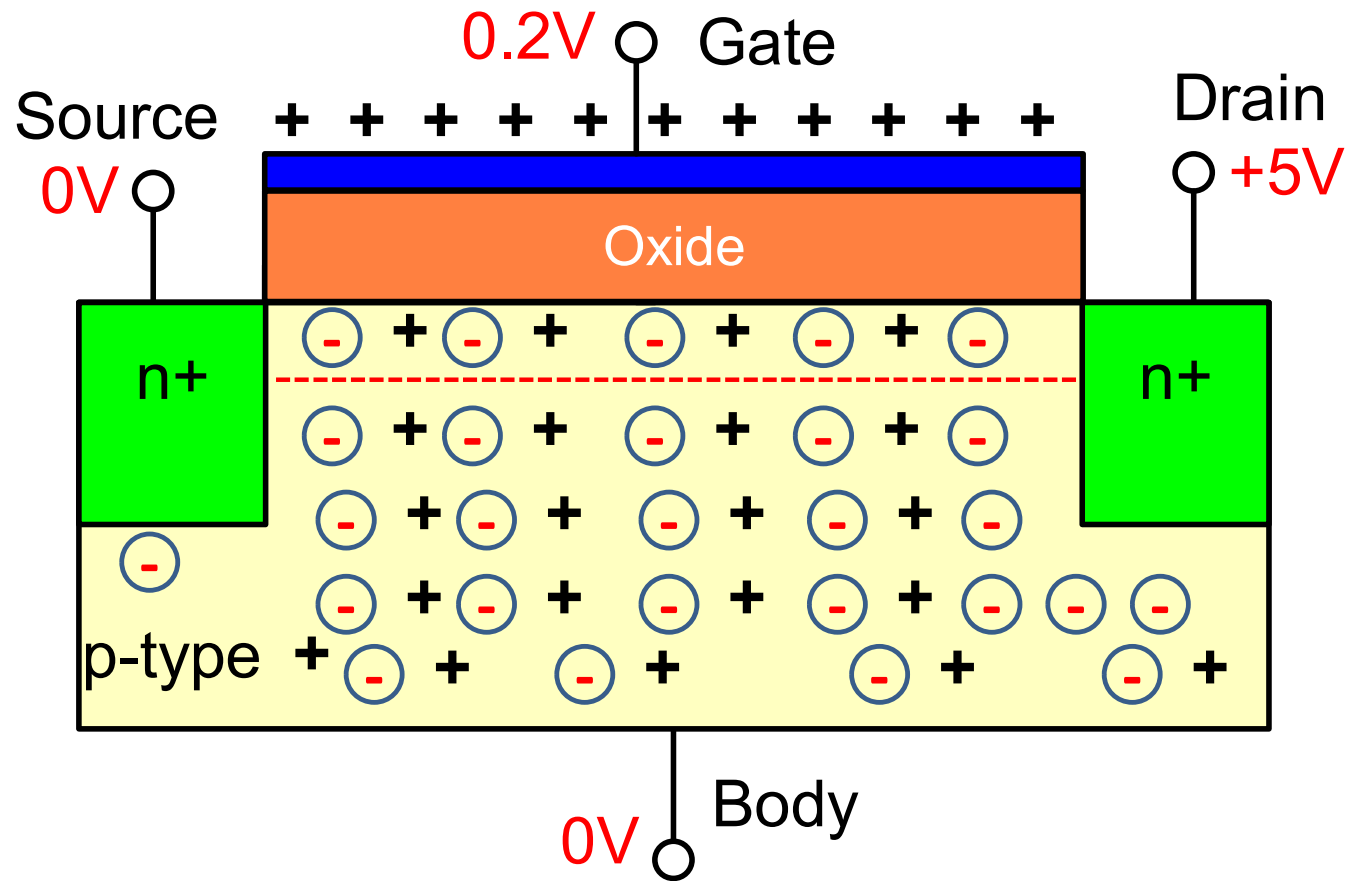
The invention relates to a method of and apparatus for controlling the flow of an electric current between two terminals of an electrically conducting solid by establishing a  
5 third potential between said terminals; and is particularly adaptable to the amplification of oscillating currents such as prevail, for example, in radio communication. Heretofore, thermionic tubes or valves have been  
10 generally employed for this purpose; and the present invention has for its object to dispense entirely with devices relying upon the transmission of electrons thru an evacuated space and especially to devices of this char-  
15 acter wherein the electrons are given off from an incandescent filament. The invention has for a further object a simple, substantial and inexpensive relay or amplifier not involving the use of excessive voltages, and

# NMOS Enhancement mode transistor: Inversion Mode Transistor

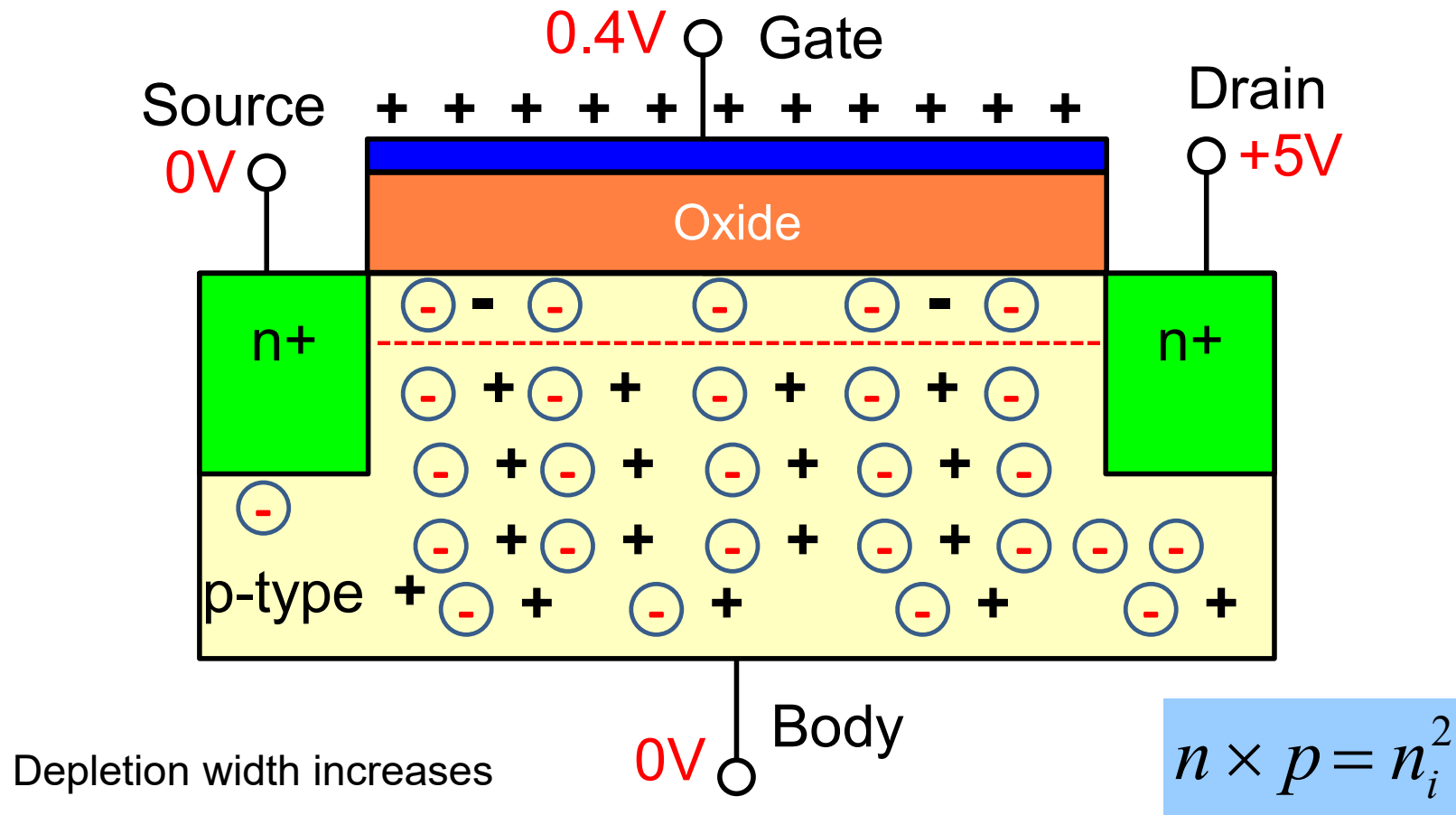




No channel exists when gate voltage is zero and current is zero as well.

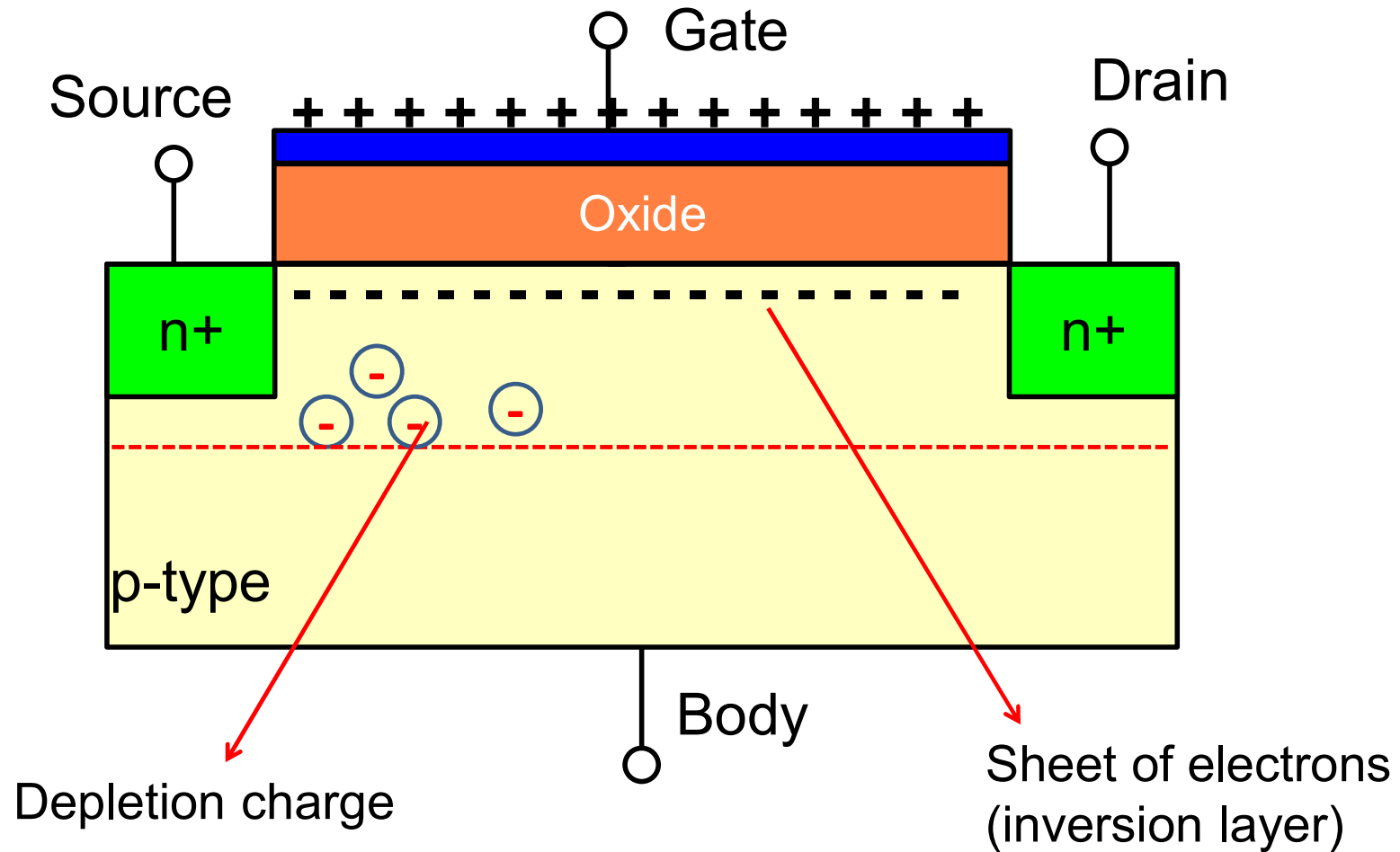


Depletion Region is formed near the Si/SiO<sub>2</sub> interface



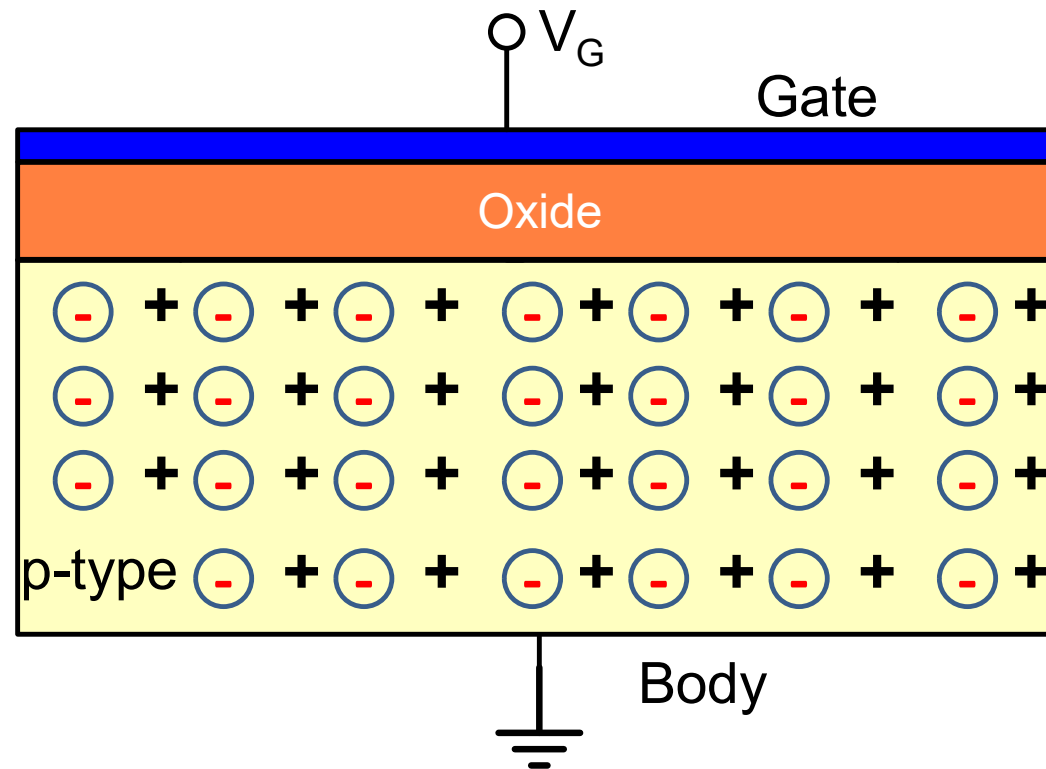
But something interesting happens: electron density at the surface also increases

At a sufficiently large voltage ( $>V_{\text{THN}}$ ) a channel of electrons forms at the Si/SiO<sub>2</sub> interface.





## Conductivity modulation at the surface?

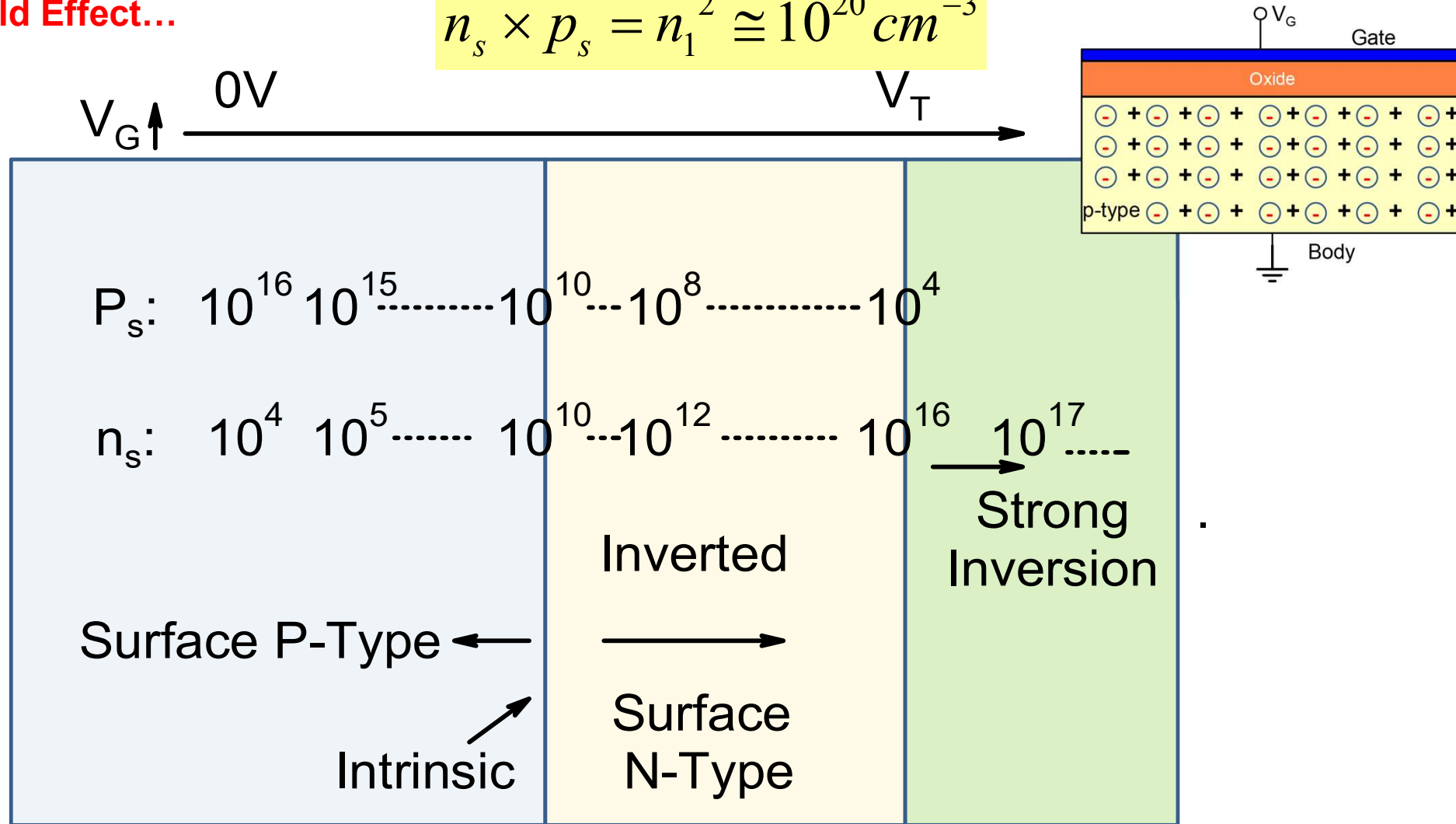


$$p = N_A = 10^{16} \text{cm}^{-3}$$

$$n = \frac{n_i^2}{p} \cong 10^4 \text{cm}^{-3}$$

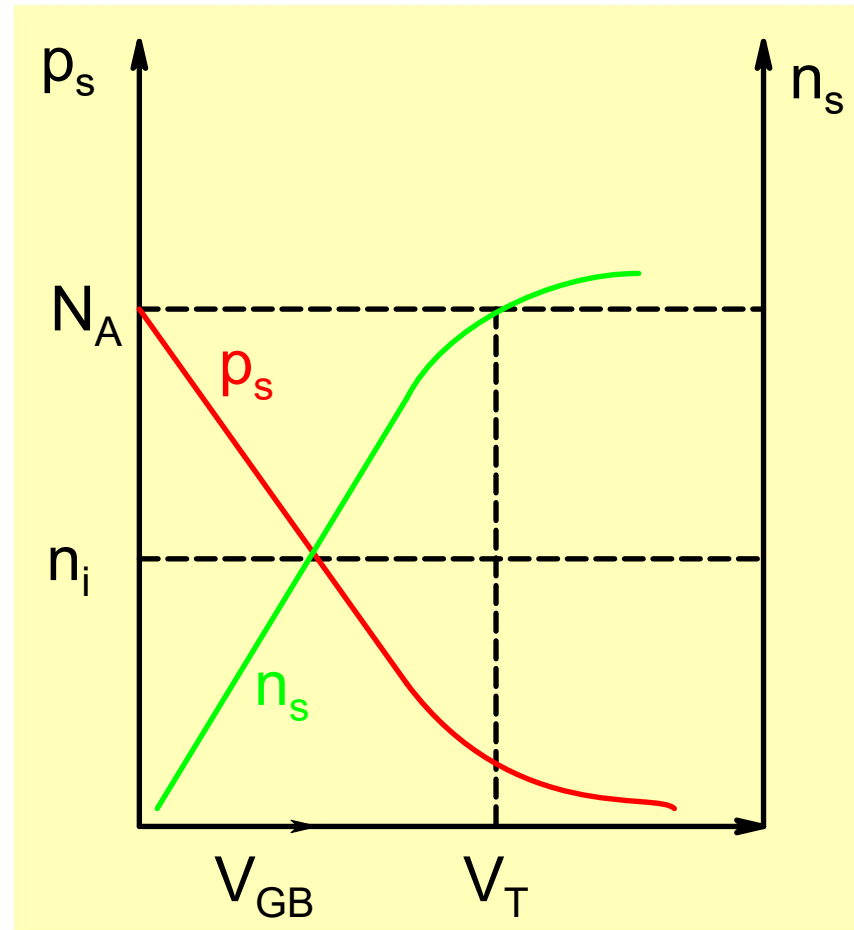
Field Effect...

$$n_s \times p_s = n_1^2 \cong 10^{20} \text{ cm}^{-3}$$

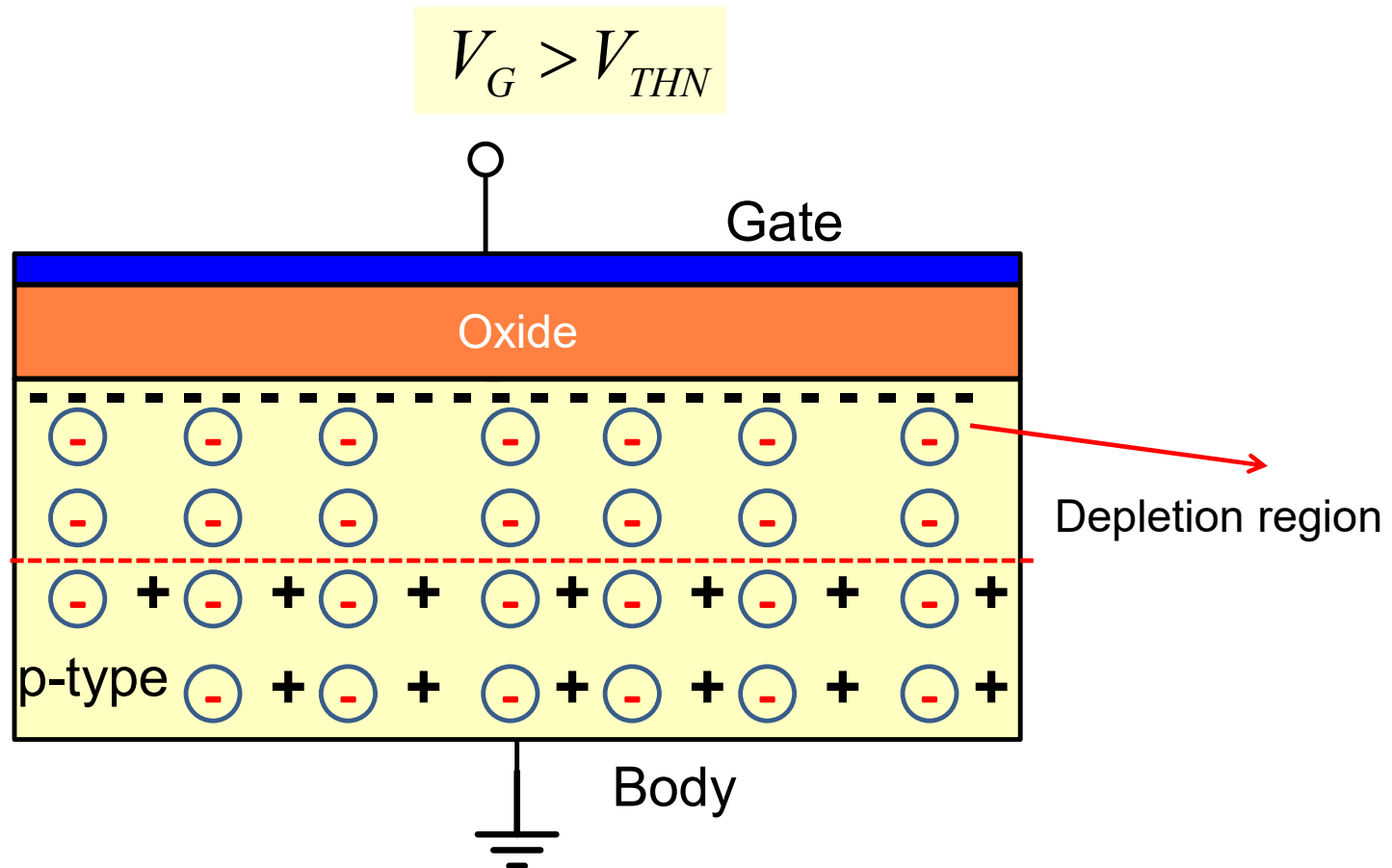


Surface carrier density can be changed from P-type to N-type

## Surface Carrier Density

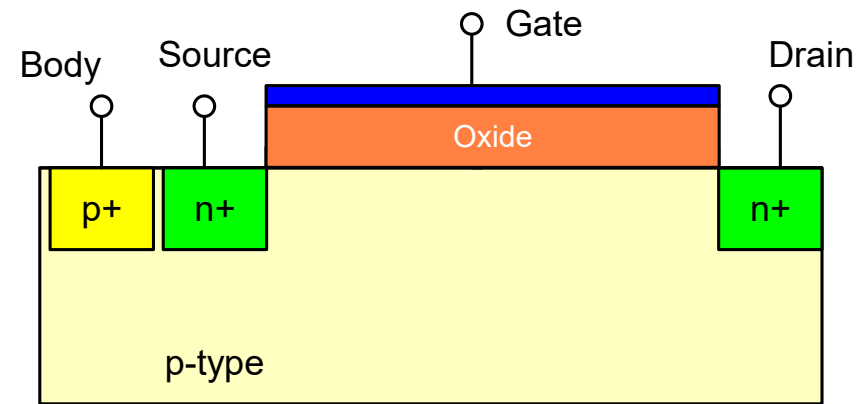
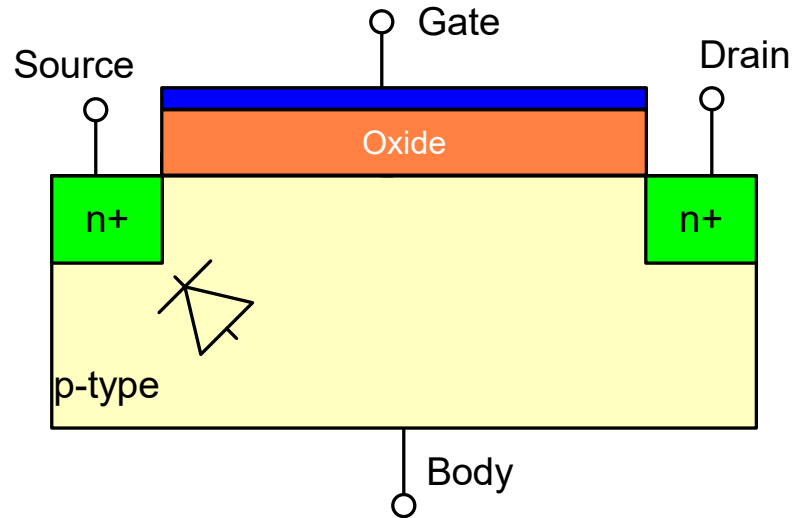
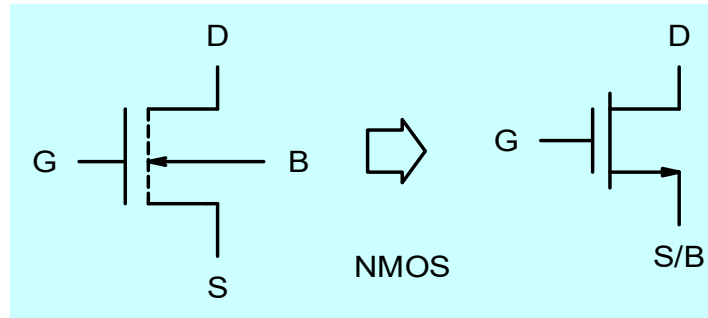


## Strong Inversion

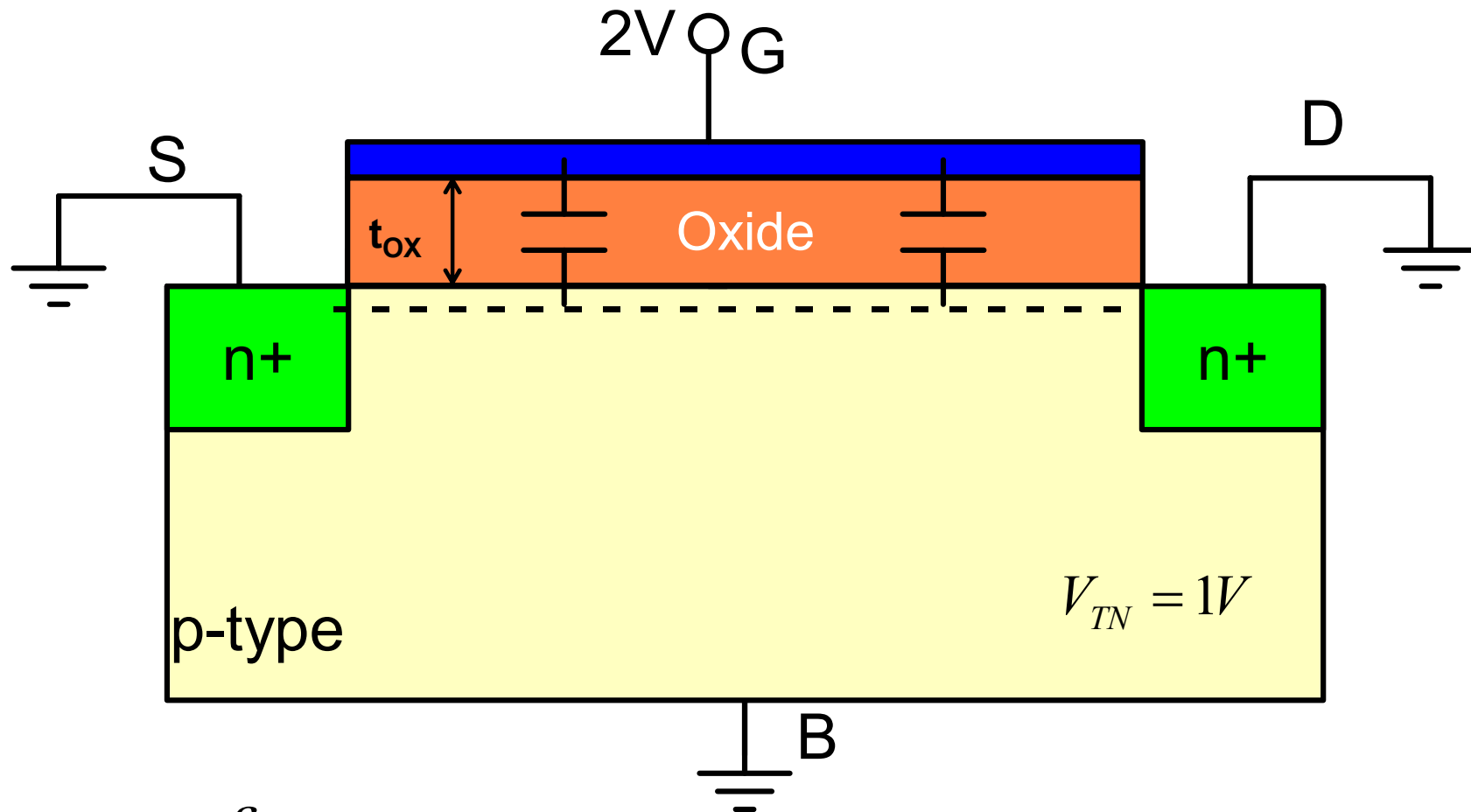


Electrons are accumulated at the surface  $n_s \gg N_A$

## Simplified Symbols and structure

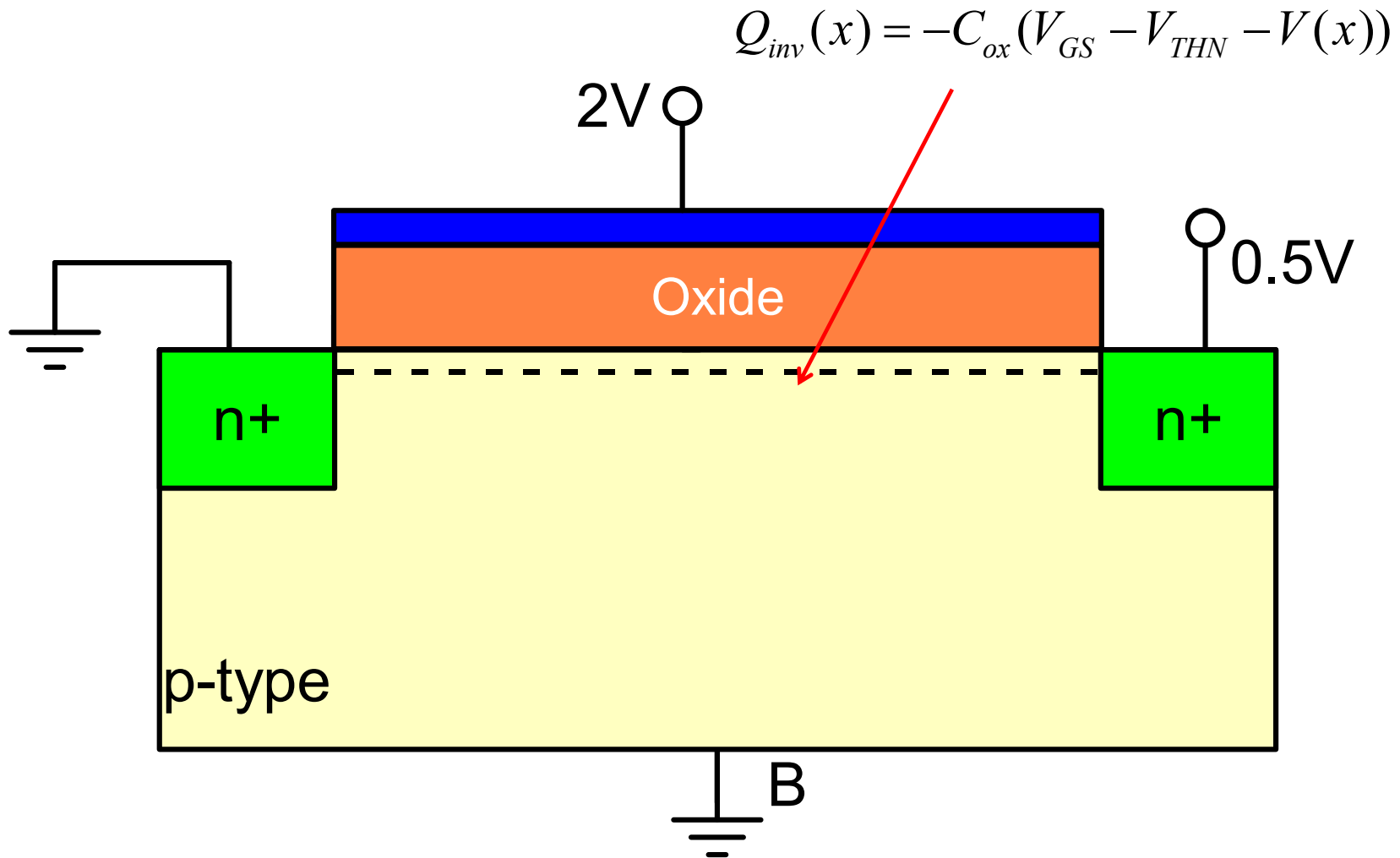


## Operation of the MOSFET

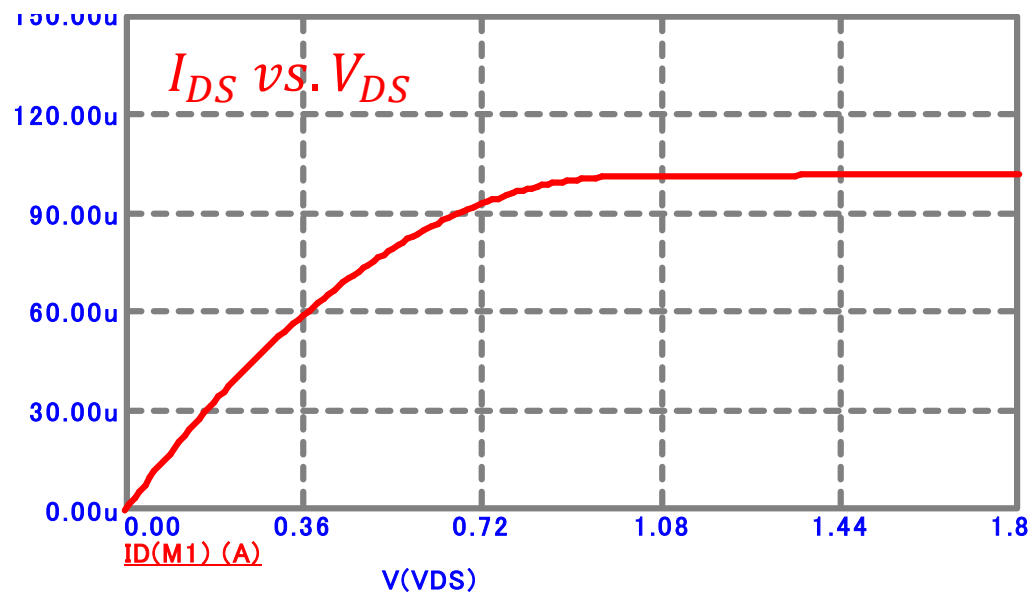
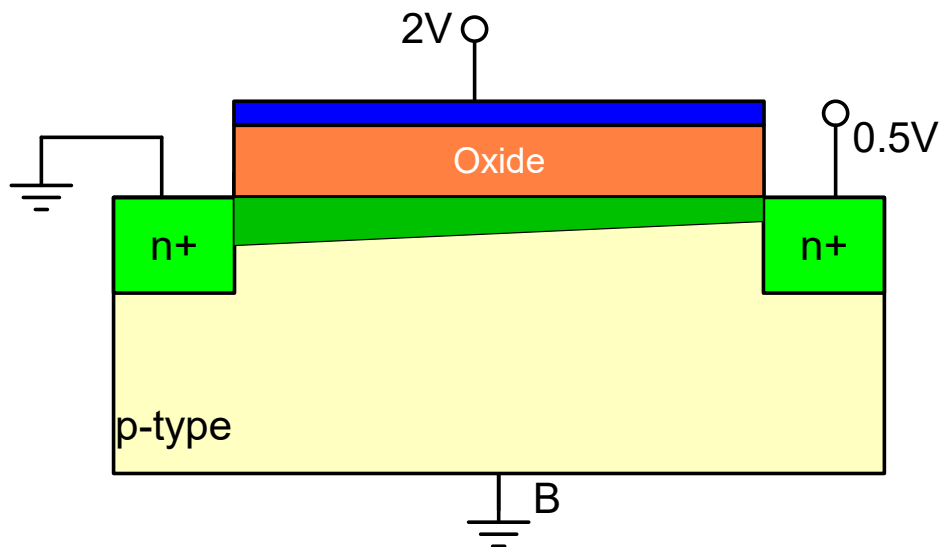
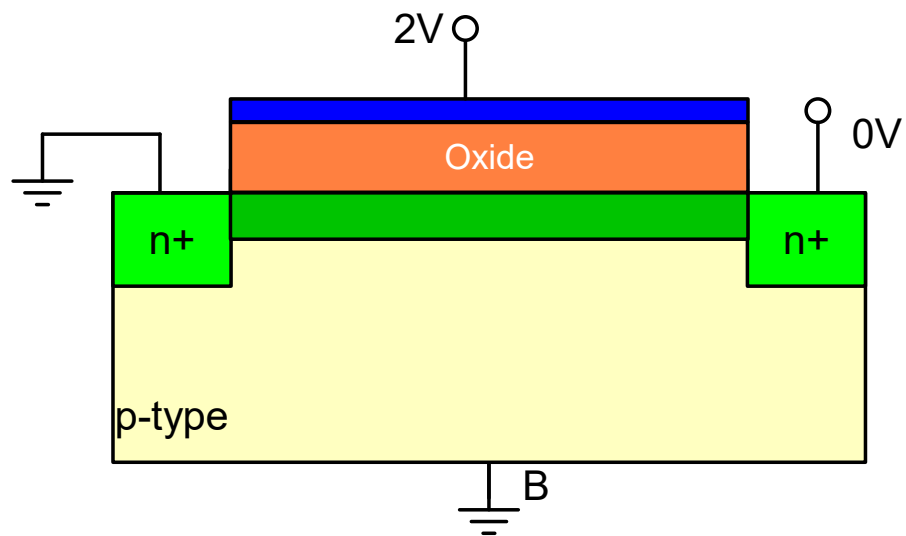


$$C'_{ox} = \frac{\epsilon_{ox}}{t_{ox}}$$

Inversion charge/area :  $Q_{inv} = -C_{ox}(V_{GS} - V_{THN})$

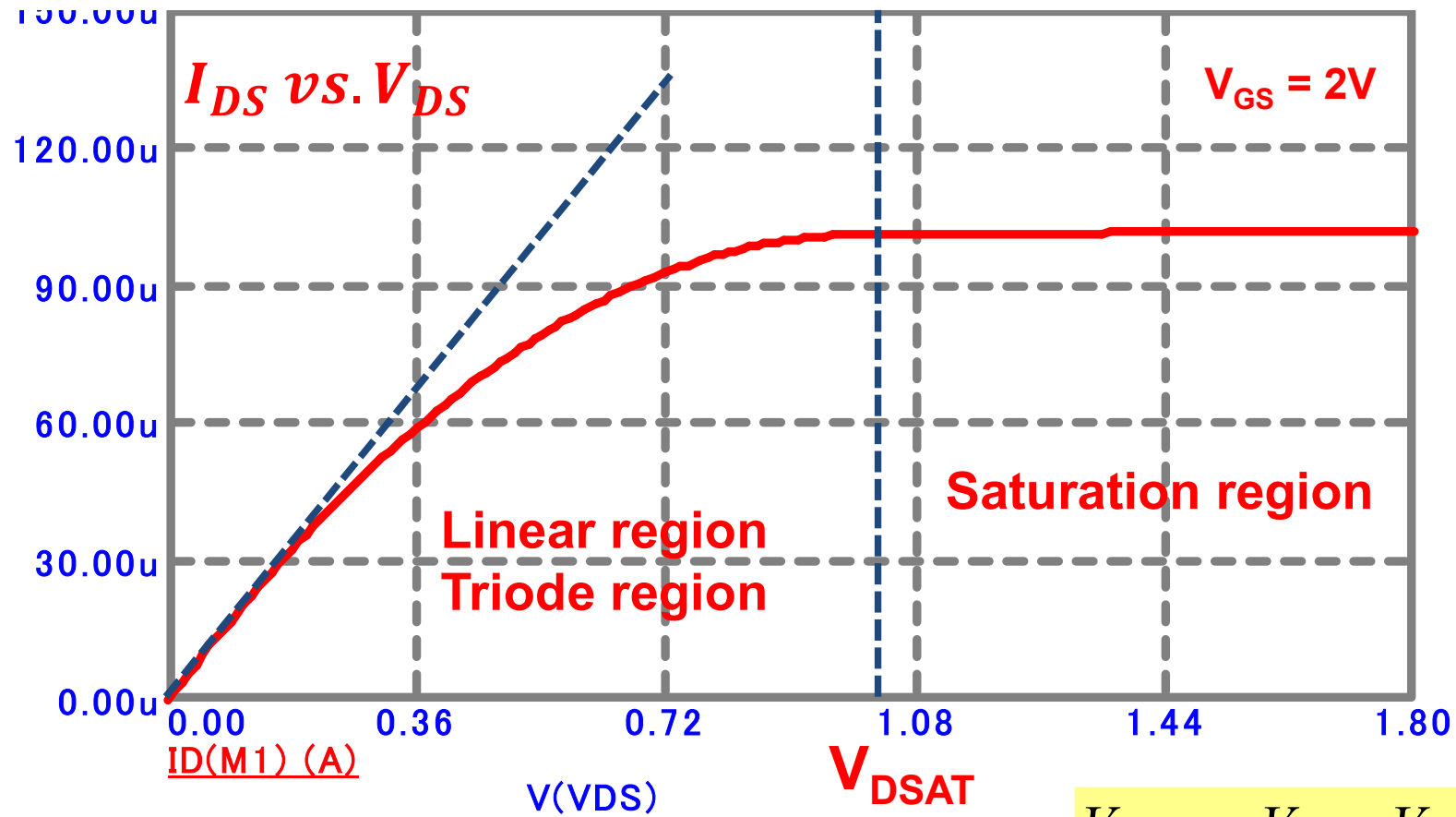


When a positive drain voltage is applied, current flows from drain to source and inversion charge density decreases from source to drain end.



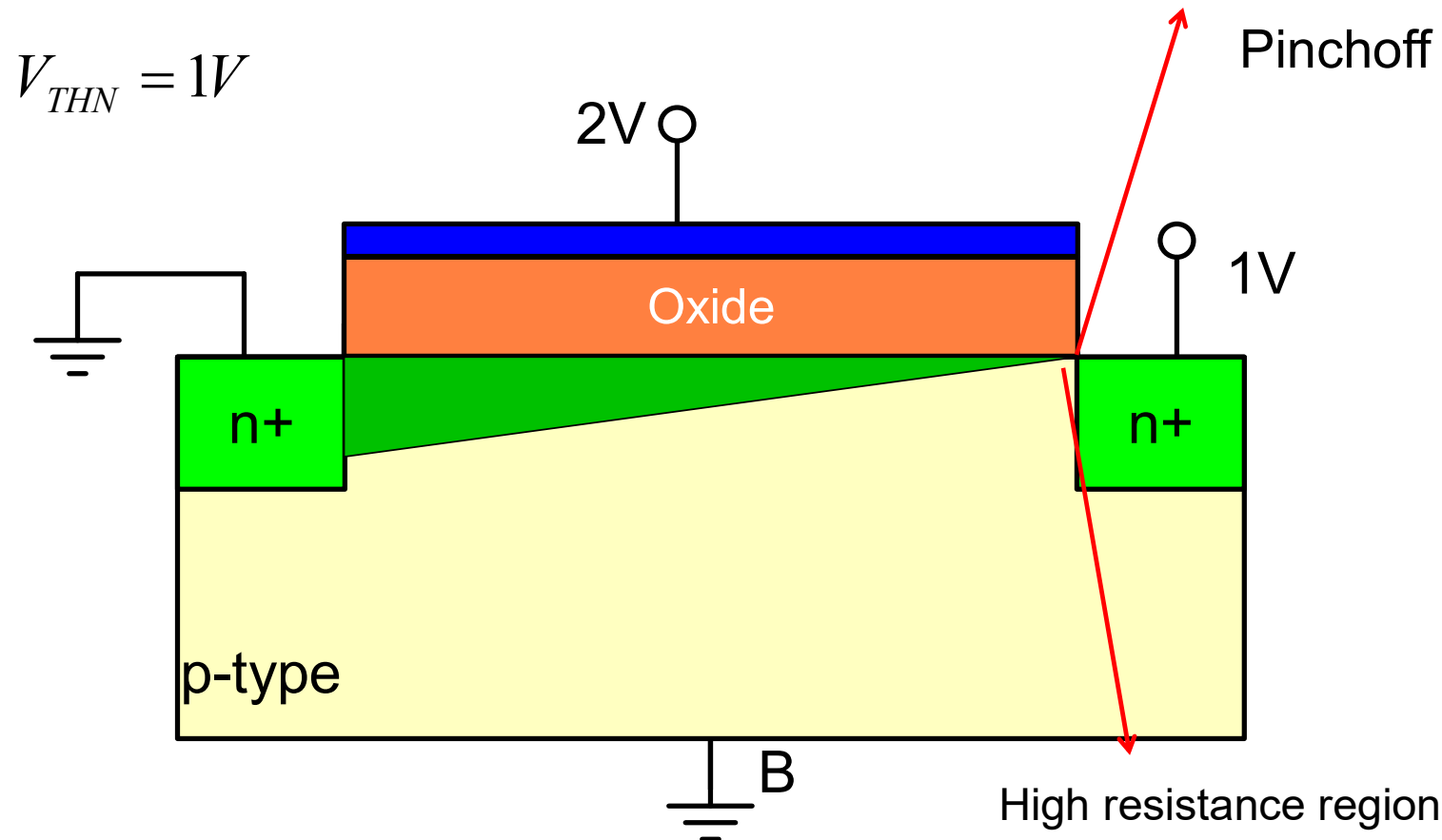


$$I_{DS} = \frac{V_{DS}}{R_{ch}} > 0$$

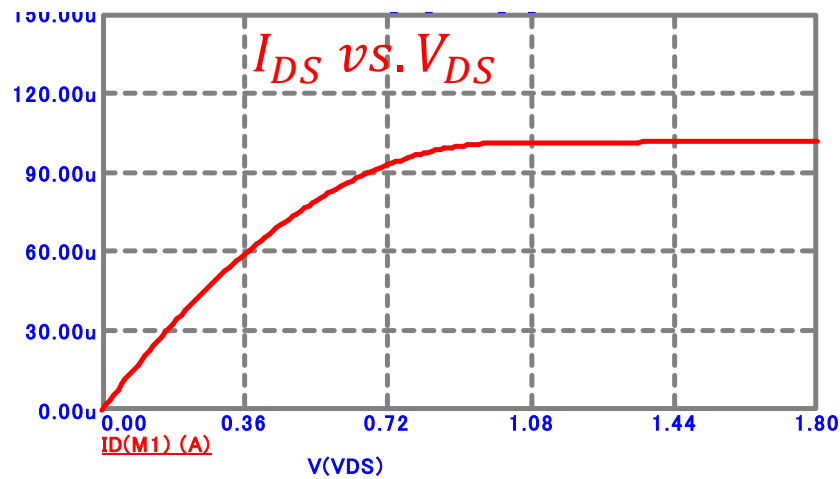
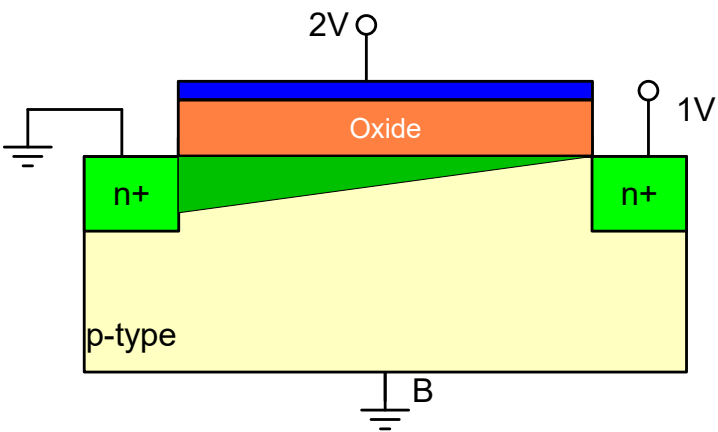
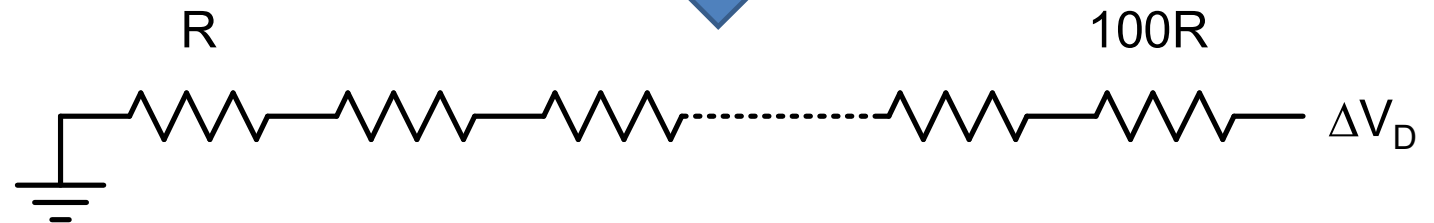
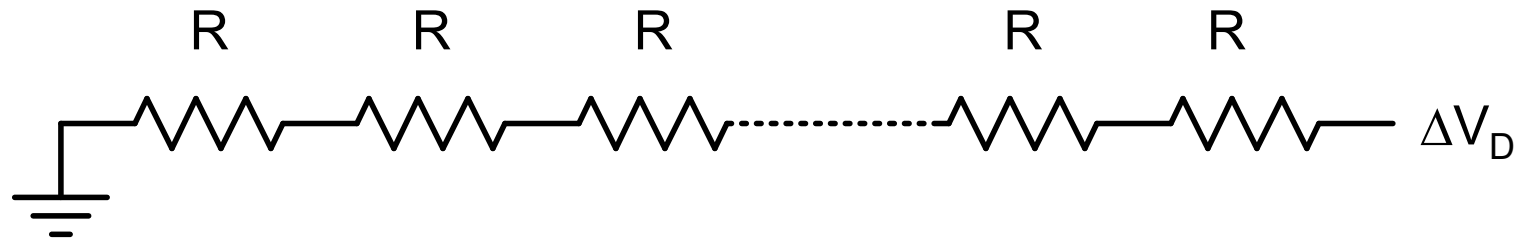
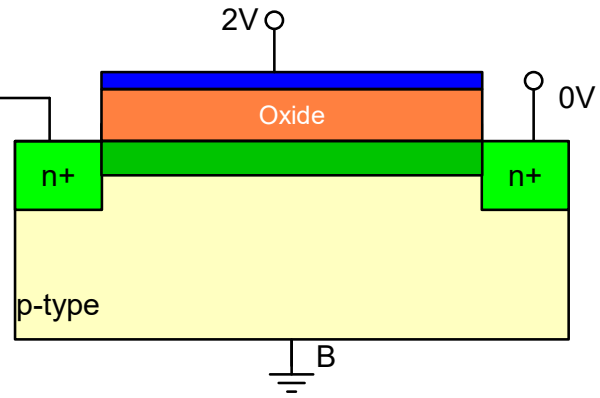


$$V_{DSAT} = V_{GS} - V_{THN}$$

$$Q_{inv}(x) = -C_{ox}(V_{GS} - V_{THN} - V(x)) \cong -C_{ox}(2 - 1 - 1) = 0$$

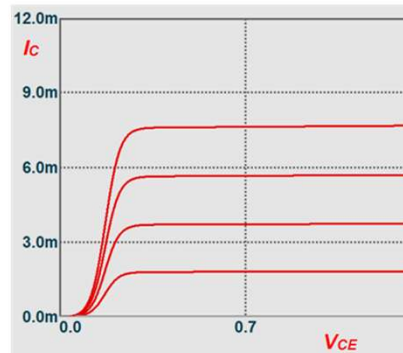
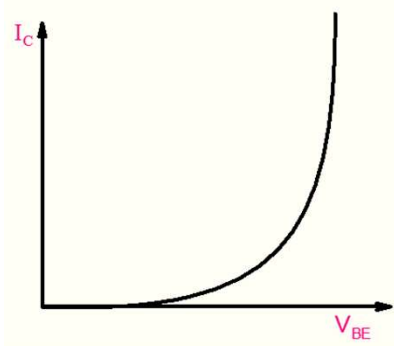
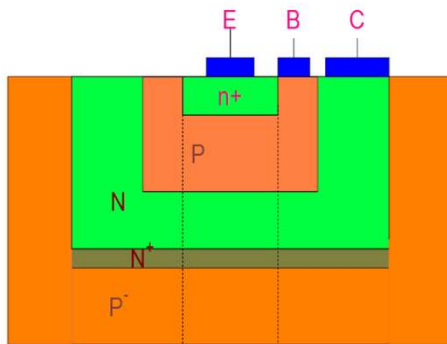


Any further increase in drain bias is absorbed in a small region next to the drain and rest of channel is not much affected and thus current becomes constant.



$$\frac{\partial I_{DS}}{\partial V_{GS}} \gg \frac{\partial I_{DS}}{\partial V_{DS}}$$

# BJT



# MOSFET

